



GISAXS/SAXS Studies of Nanoparticle Assemblies at Solid/Fluid Interfaces

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- **Why GISAXS/SAXS and nanoparticles?**
- **Basics of GISAXS**
- **Nanoparticle assemblies**
 - solid surfaces
 - monolayers - tracking of self-assembly, surfactant removal
 - multilayers – the role of vertical correlation
 - liquid surfaces
 - time-resolved GISAXS – formation of monolayer
- **GISAXS in applied nanoparticle science**
 - solar cells, strain gauges, spintronics
- **Summary and outlook**



**WINTER SCHOOL
OF SYNCHROTRON
RADIATION**

31.1. - 4.2.2011 Liptovský Ján, Slovakia

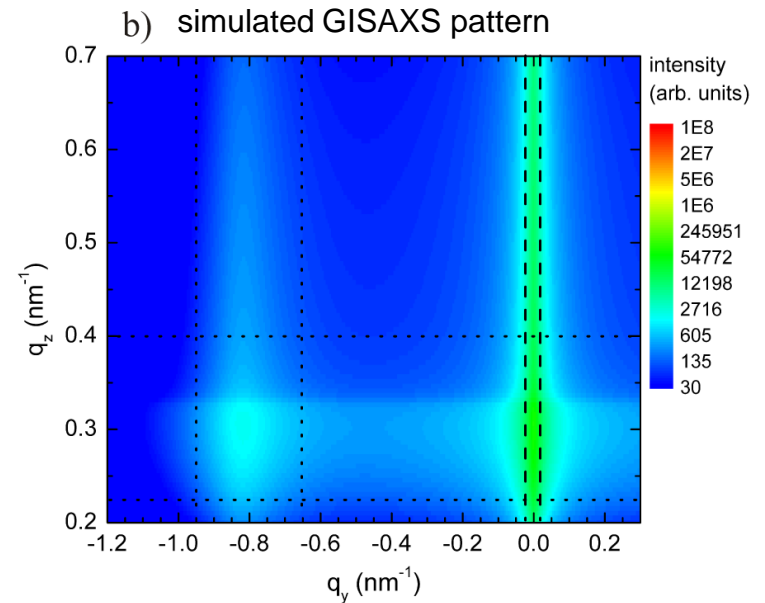
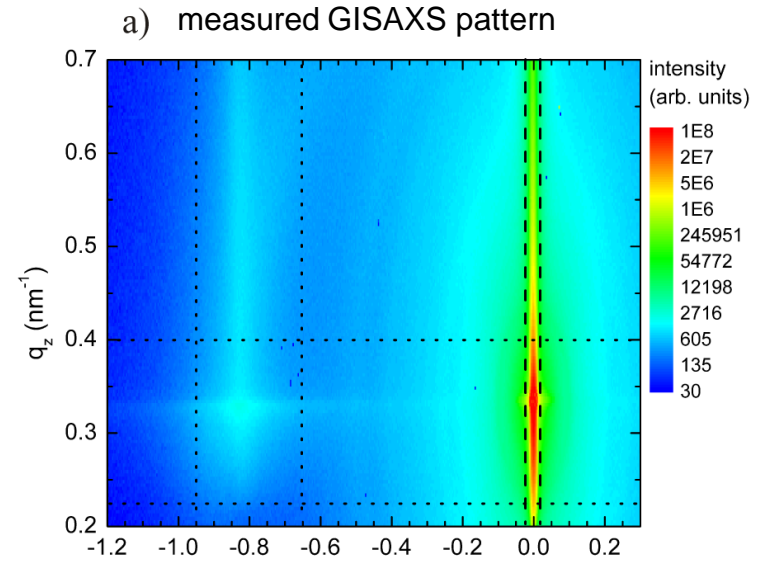
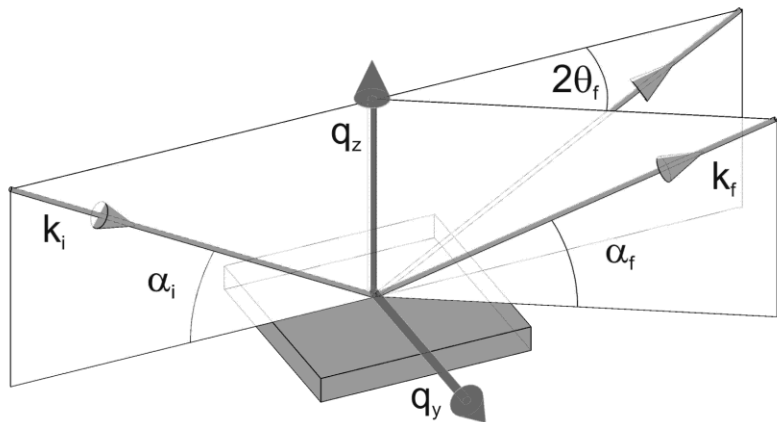
Why GISAXS and nanoparticles?

The advantages of GISAXS:

- simple experimental setup
- large lateral q -space available ($>10\times$)
- at $\alpha_i, \alpha_f > 3\alpha_c$ simple BA theory is valid
(we can avoid dynamic scattering processes like Yoneda peaks, etc.)
- laboratory table-top systems available
(Bruker Nanostar equipped with Incoatec $1\mu\text{S}$ X-ray source, etc.)

Measurement geometry / GISAXS

(grazing-incidence small-angle X-ray scattering)



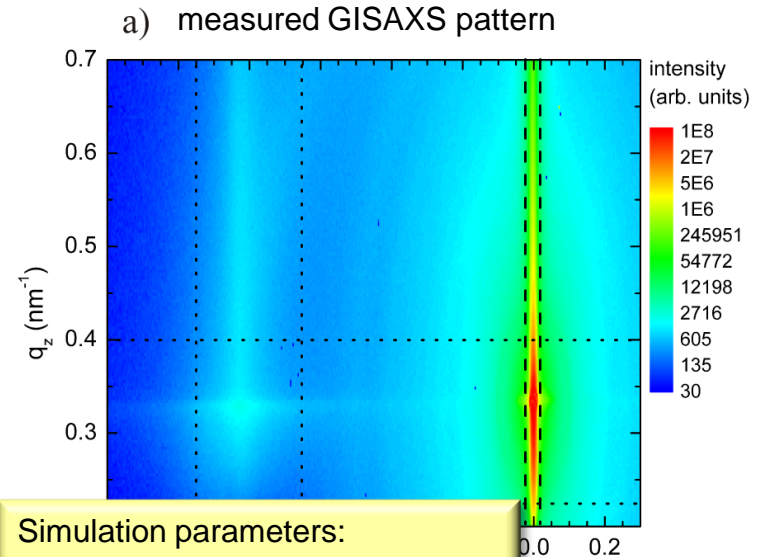
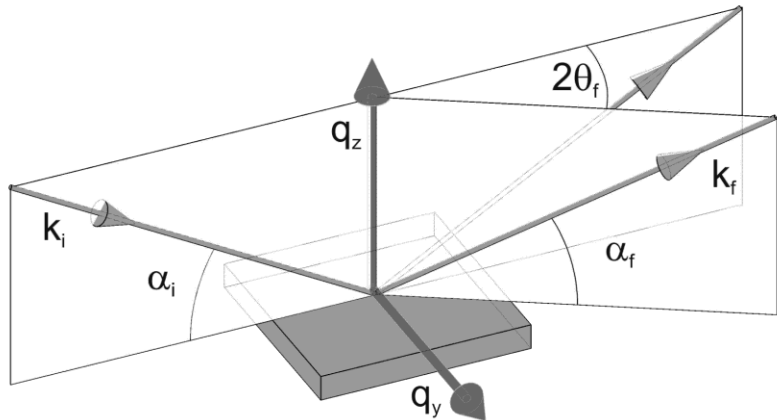
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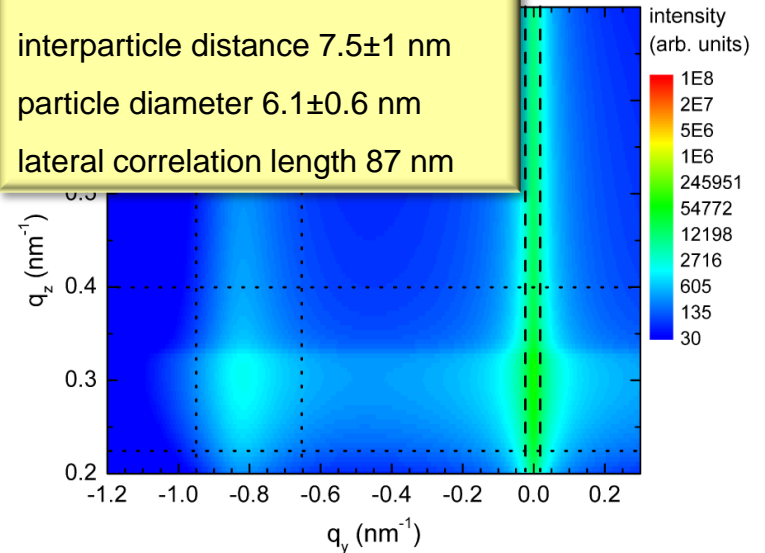
Simulation parameters:

DWBA approach and paracrystal model

interparticle distance 7.5 ± 1 nm

particle diameter 6.1 ± 0.6 nm

lateral correlation length 87 nm



Basics of GISAXS

Advantages:

- non-destructive technique allowing inspection of buried clusters and interfaces
- in contrast to microscopy we average over sample surface/volume
- working under all conditions (enables in-situ screening/control)
- due to small angle of incidence can be combined with many other techniques
- changing the incidence angle controls the penetration depth

Disadvantages:

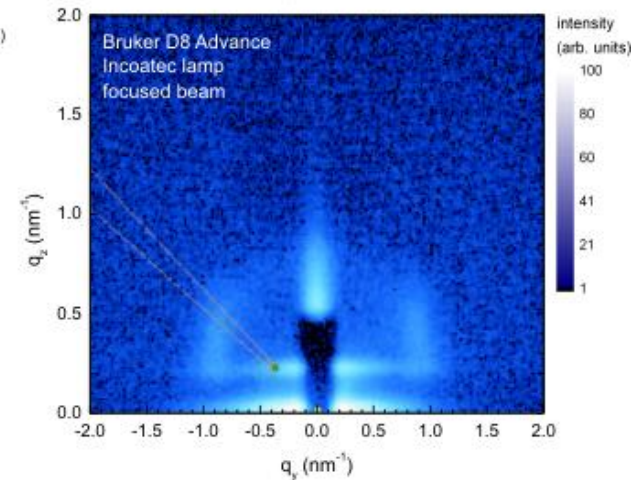
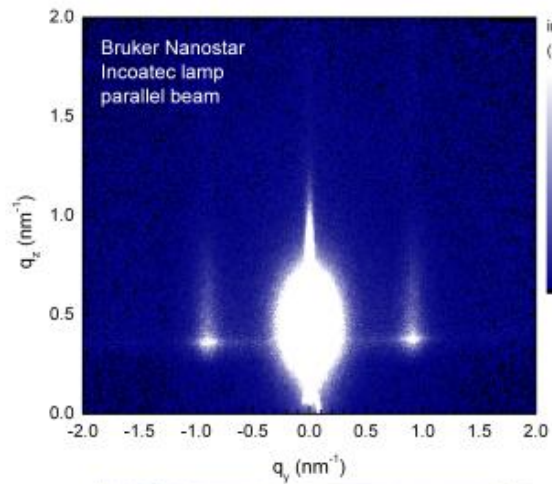
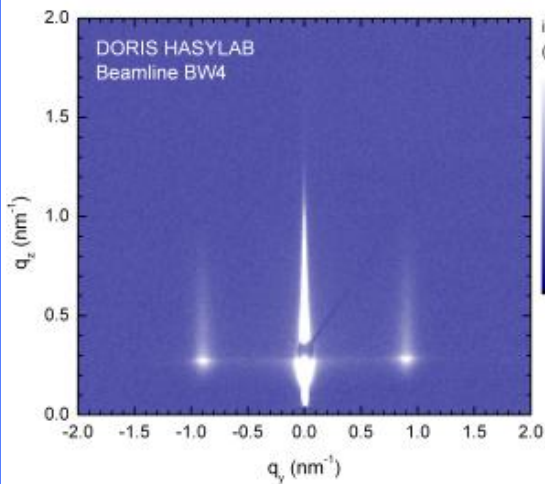
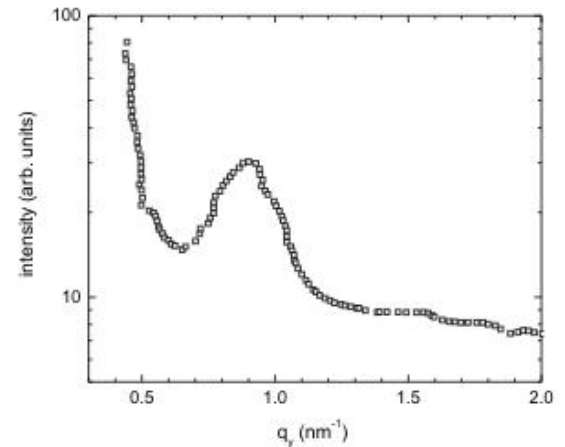
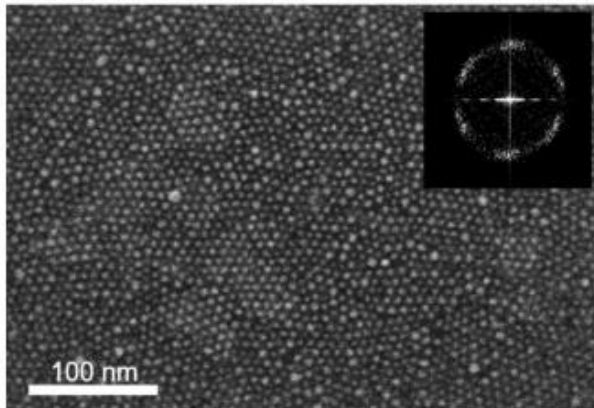
- transformation from reciprocal to real space needs an appropriate model
- we always measure statistical averages over ensemble of entities

As with most techniques, X-ray scattering also has some drawbacks:

- (i) The use of synchrotron radiation is nearly mandatory because the collected signal scales with the amount of material, which can be rather small (of the order of the monolayer).

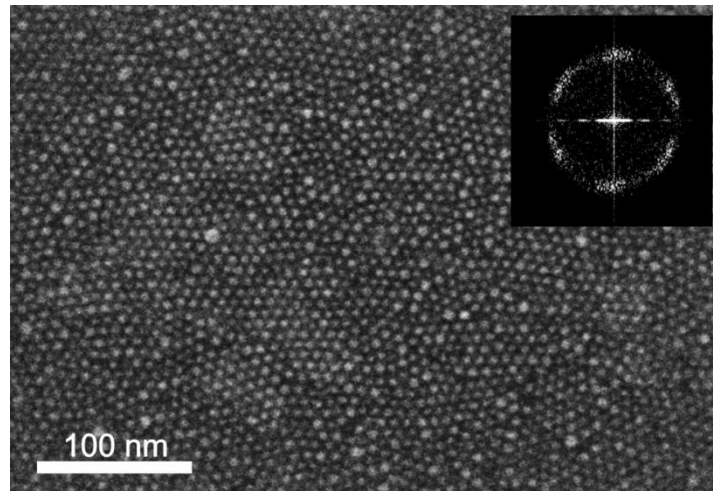
Basics of GISAXS / from synchrotron to table-top

SEM image of self-assembled nanoparticle 2D array.

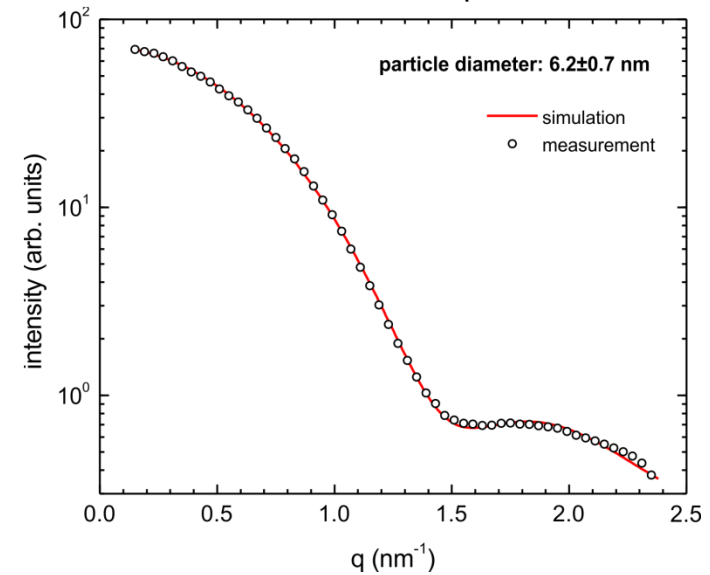


Nanoparticle self-assembly (SEM, SAXS, XRR, GID)

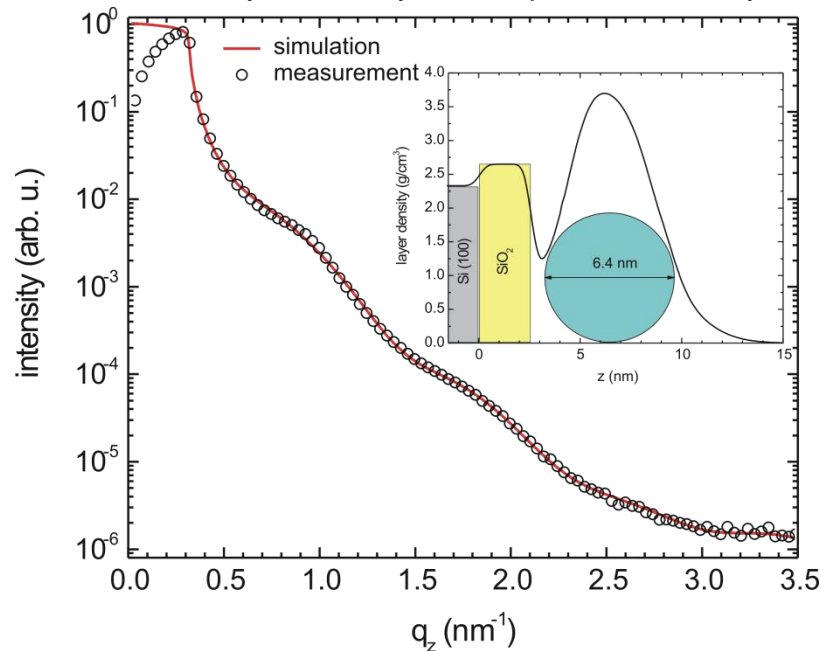
SEM image of self-assembled nanoparticle 2D array.



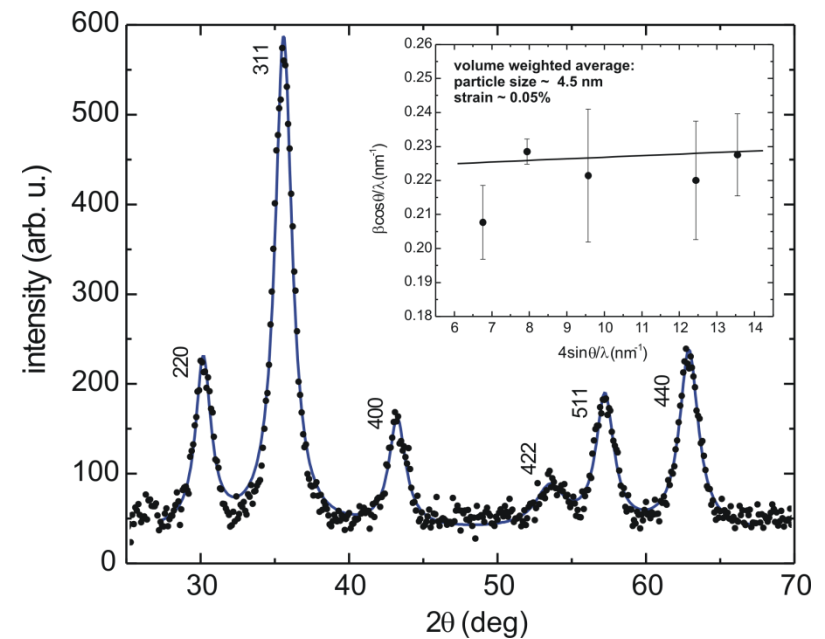
SAXS from diluted nanoparticle solution



X-ray reflectivity of nanoparticle 2D array



GI-XRD of nanoparticle multilayer

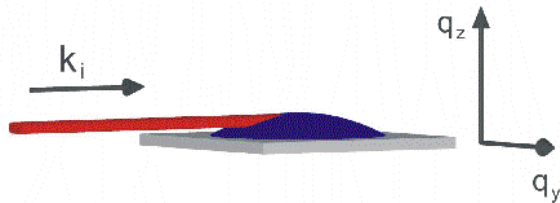


Tracking the origin of nanoparticle self-assembly

Observation of self-assembly of magnetic nanoparticles plays an important role in basic and applied research.

I. Dynamics of nanoparticles dispersed in slowly evaporating solvents (gold nanoparticles in water)

Static GISAXS allows for reciprocal space characterization of selected point of evaporating colloidal drop.



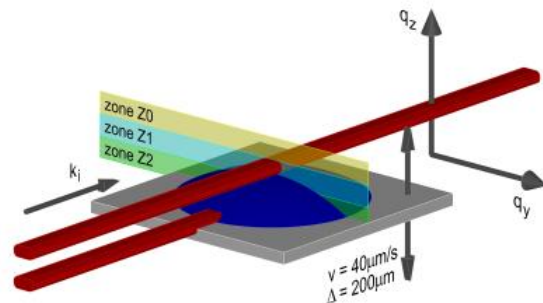
S. Narayanan et al., Phys. Rev. Lett. 93, 135503 (2004)

S. V. Roth et al., App. Phys. Lett. 91, 091915 (2007)

P. Siffalovic et al., Phys. Rev. B 76, 195432 (2007)

II. Dynamics of nanoparticles dispersed in rapidly evaporating solvents (iron oxide nanoparticles in toluene)

Scanning GISAXS scheme provides information on reciprocal space from various points located near the surface or inside the drop.

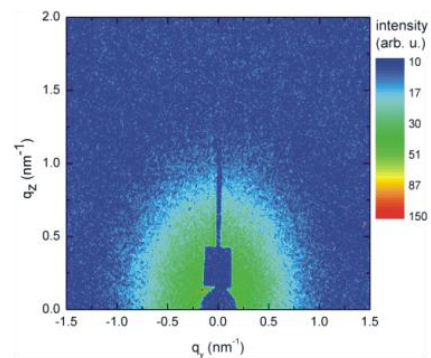
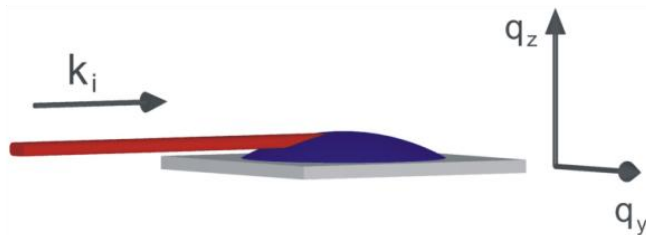


P. Siffalovic et al., Small 4 (12), 2222 (2008)

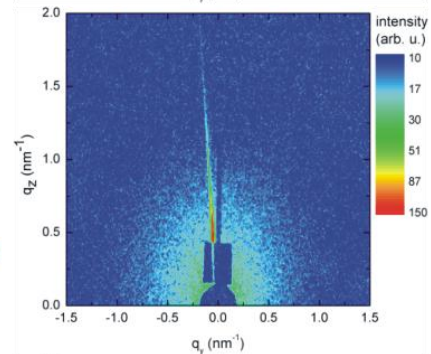
Static GISAXS mode

Measurement geometry - drop mode

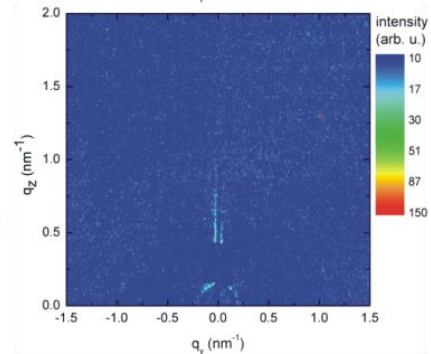
I. scattering from the drop volume



II. scattering from the drop surface

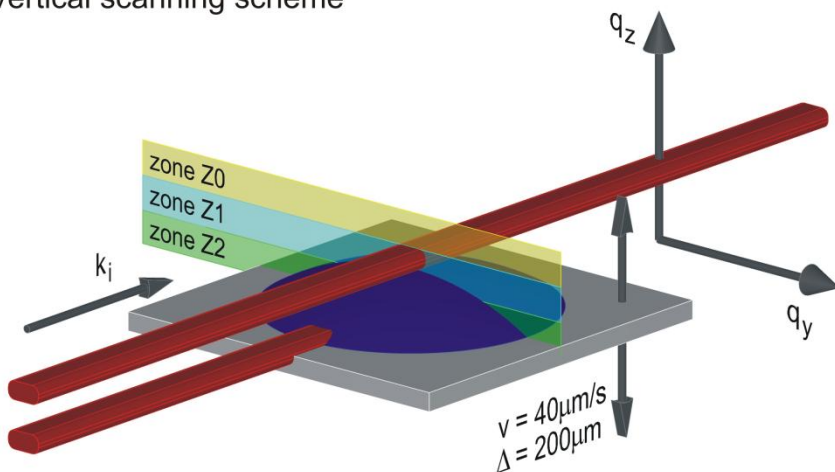


III. direct beam



Scanning GISAXS mode – vertical scanning mode

Vertical scanning scheme



Legend:

QYT map - q_z integrated within $\langle 0.22, 0.4 \rangle \text{ nm}^{-1}$

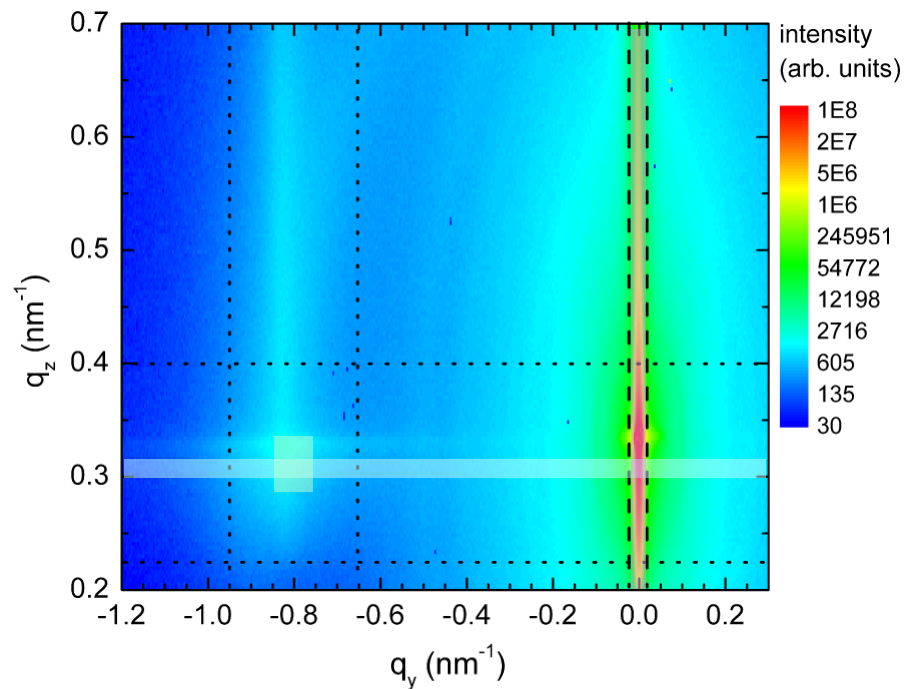
QZT map - q_y integrated within $\langle -0.02, 0.02 \rangle \text{ nm}^{-1}$

PIS plot - q_z integrated within $\langle 0.22, 0.4 \rangle \text{ nm}^{-1}$
- q_y integrated within $\langle 0.65, 0.95 \rangle \text{ nm}^{-1}$

reflectivity plot

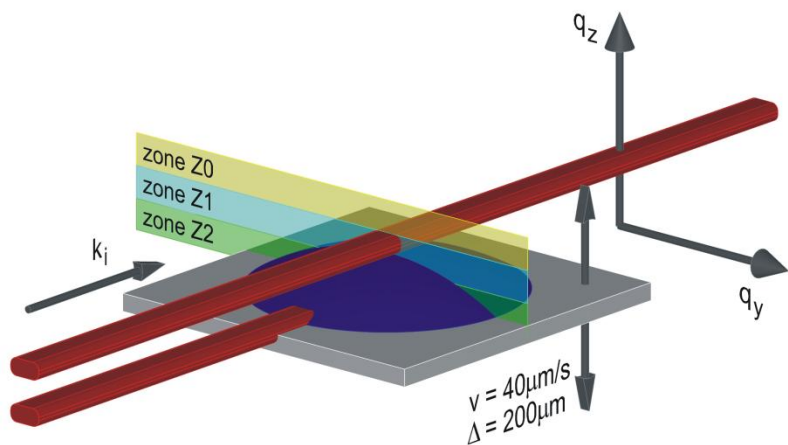
- q_y integrated within $\langle -0.02, 0.02 \rangle \text{ nm}^{-1}$
- q_z integrated within $\langle 0.29, 0.35 \rangle \text{ nm}^{-1}$

ACOD - adjusted R^2 (coefficient of determination)



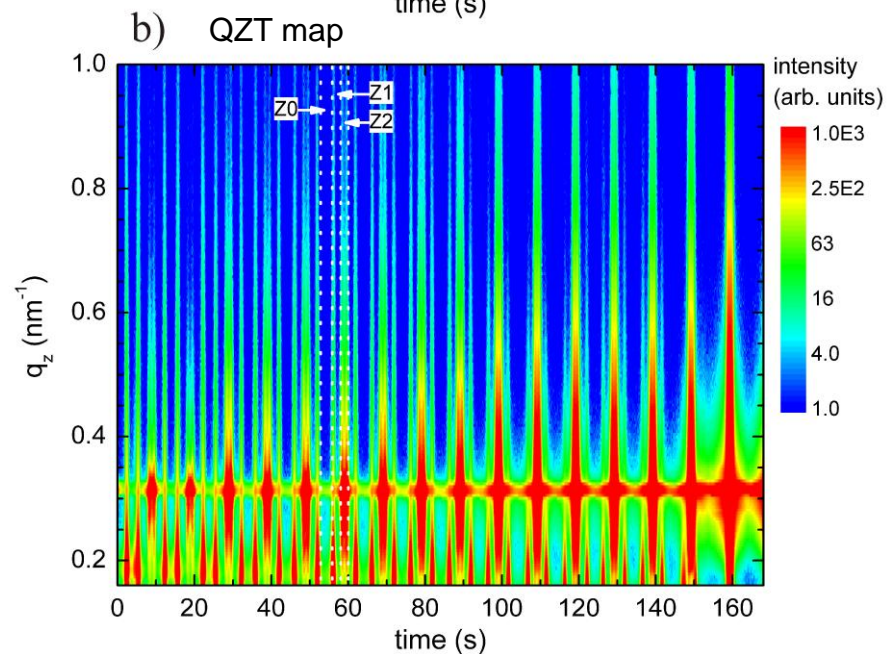
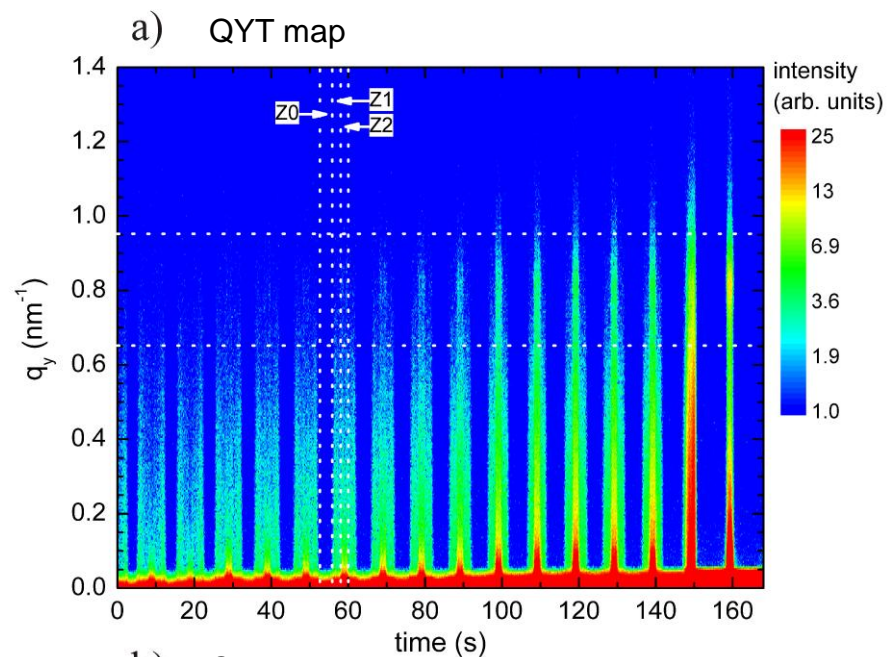
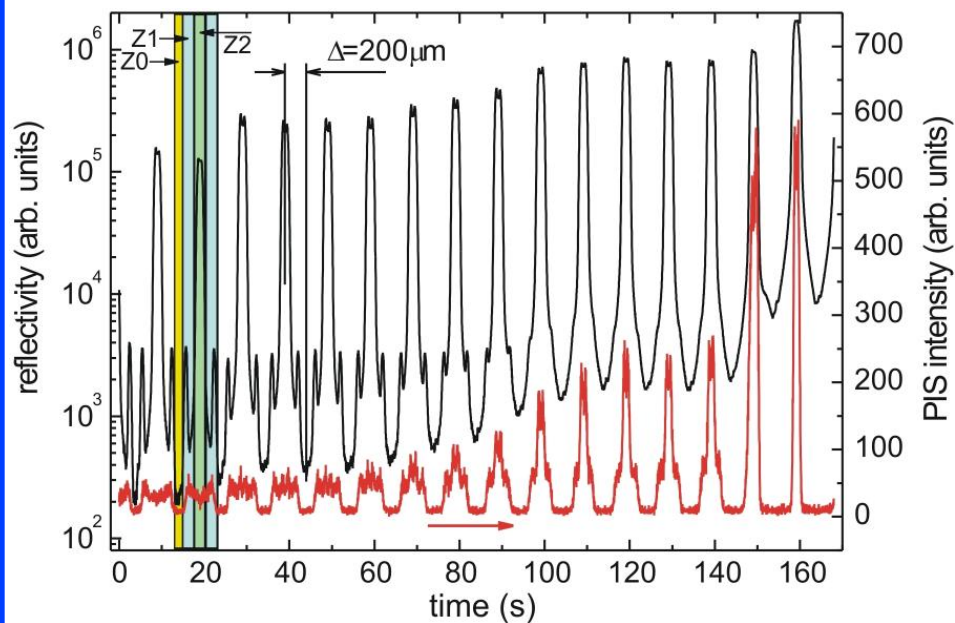
Short acquisition time compensates for spatial smearing which is in order of 1 μm for vertical scanning

Scanning GISAXS mode – vertical scanning mode

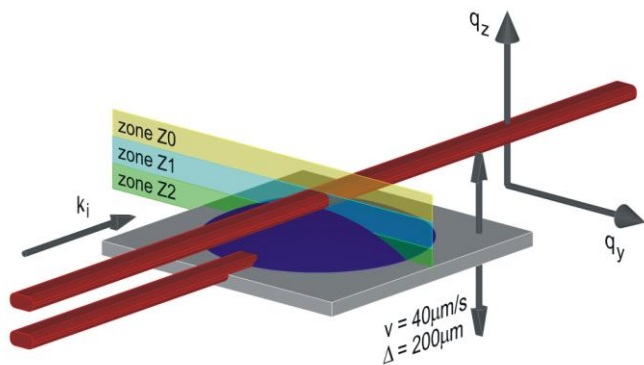


P. Siffalovic et al., Small 4 (12), 2222 (2008)

Reflectivity and PIS plot

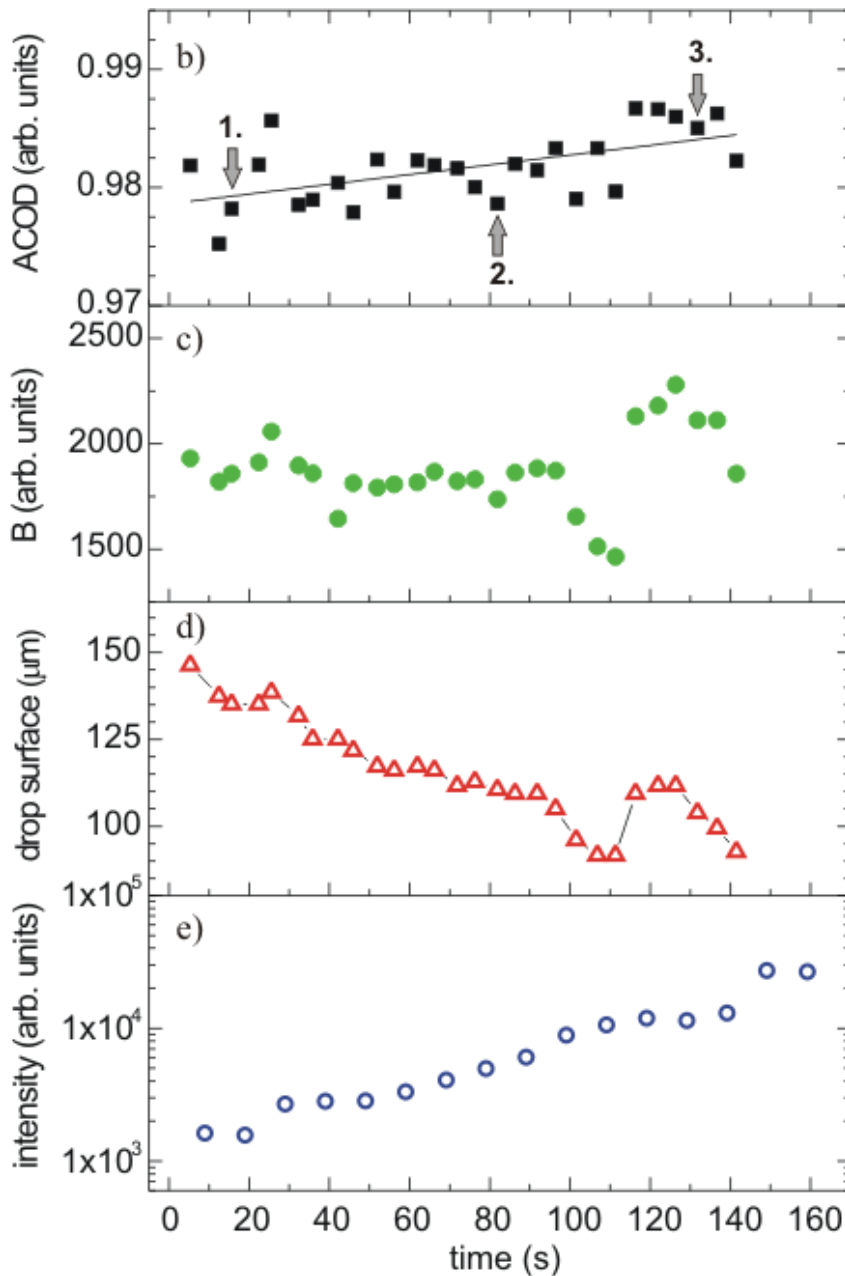
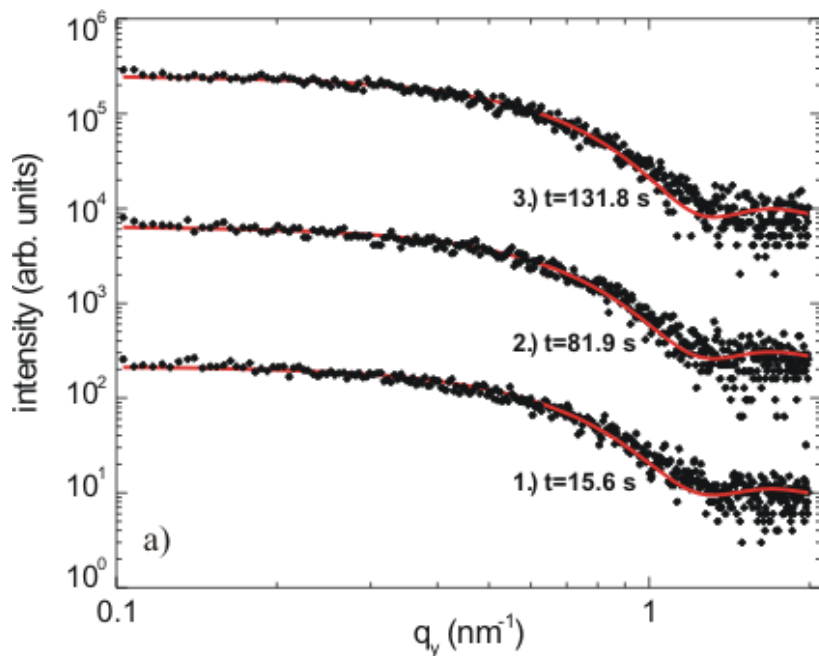


Scanning GISAXS mode – vertical scanning mode

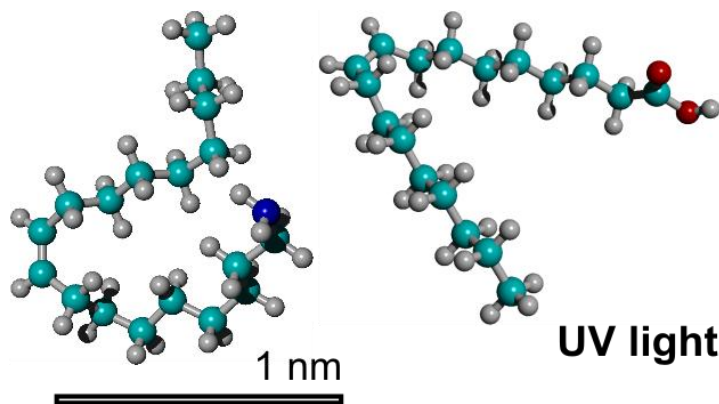


$$I(q_y) = A + B |F(q_y)|^2 S(q_y)$$

$$F(q_y) = 4\pi r^3 [\sin(q_y r) - q_y r \cos(q_y r)] / (q_y r)^3$$



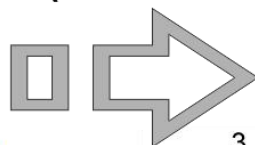
Photolysis and ozonolysis of nanoparticle surfactant



Nanoparticle surfactant:

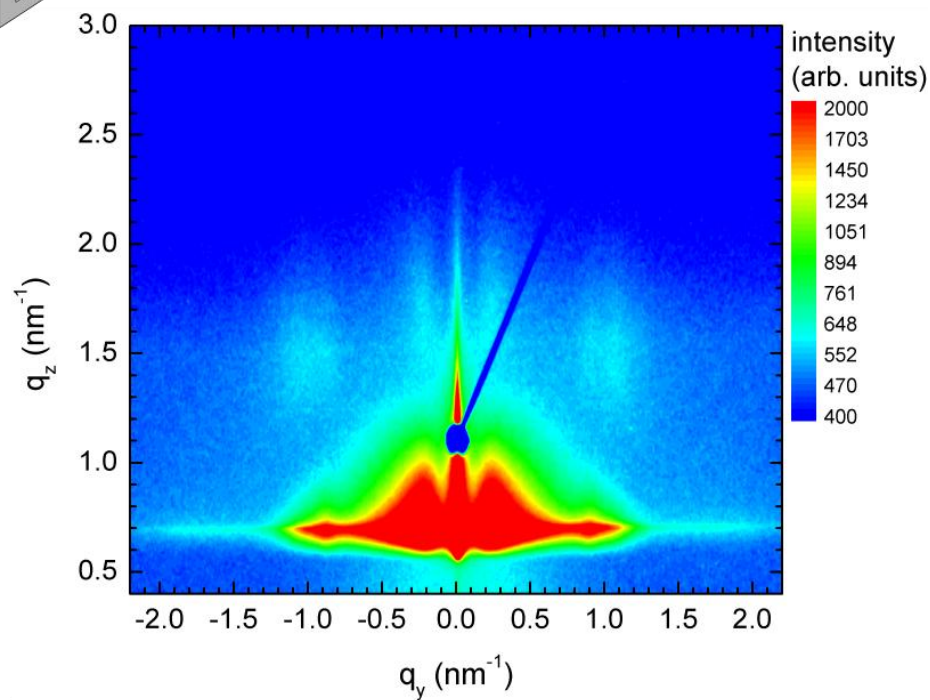
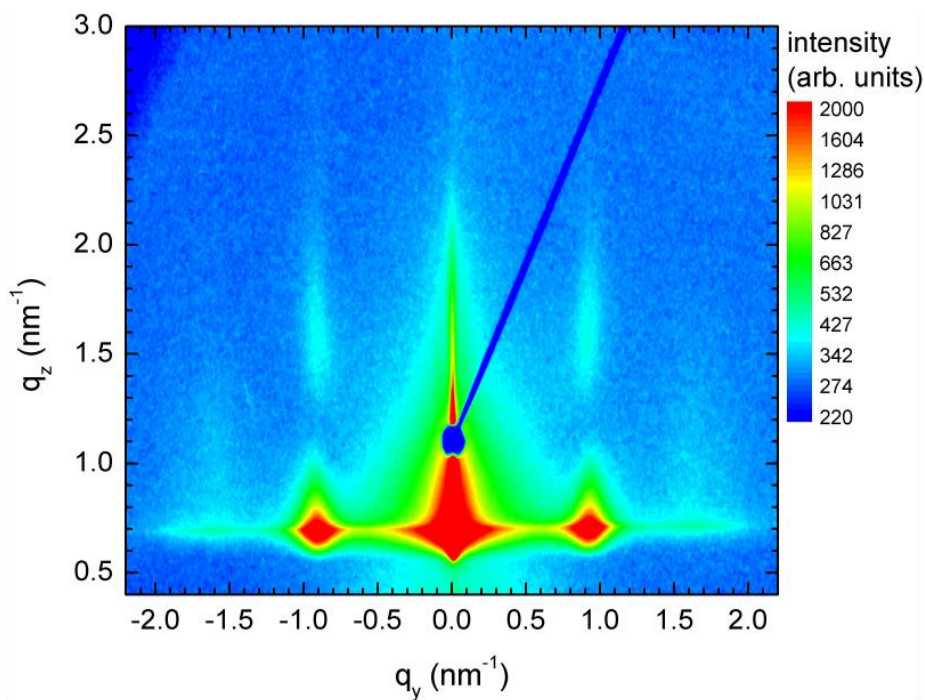
- oleic acid
- oleyl amine

UV light (4.9 eV, 6.7 eV) + O₃

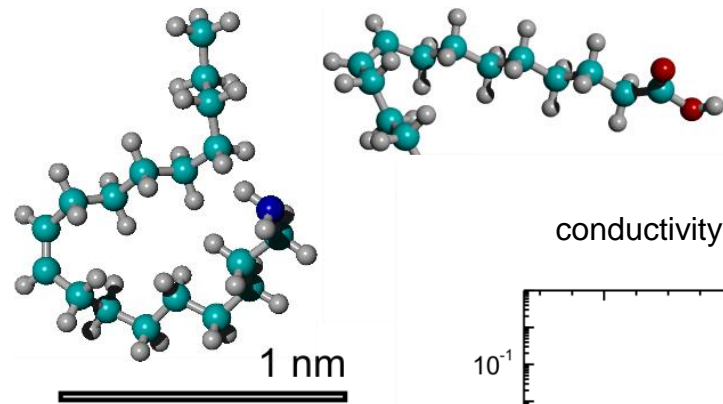


Initial self-assembled state

Final re-assembled state

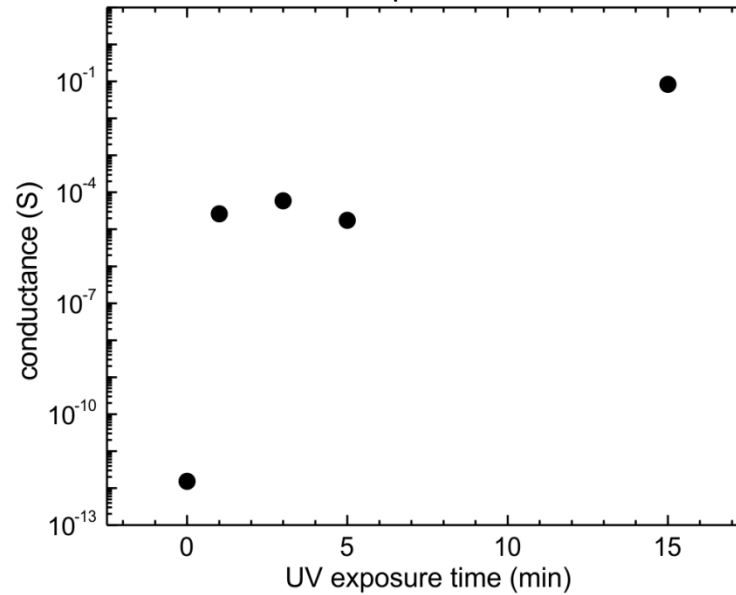


Photolysis and ozonolysis of nanoparticle surfactant

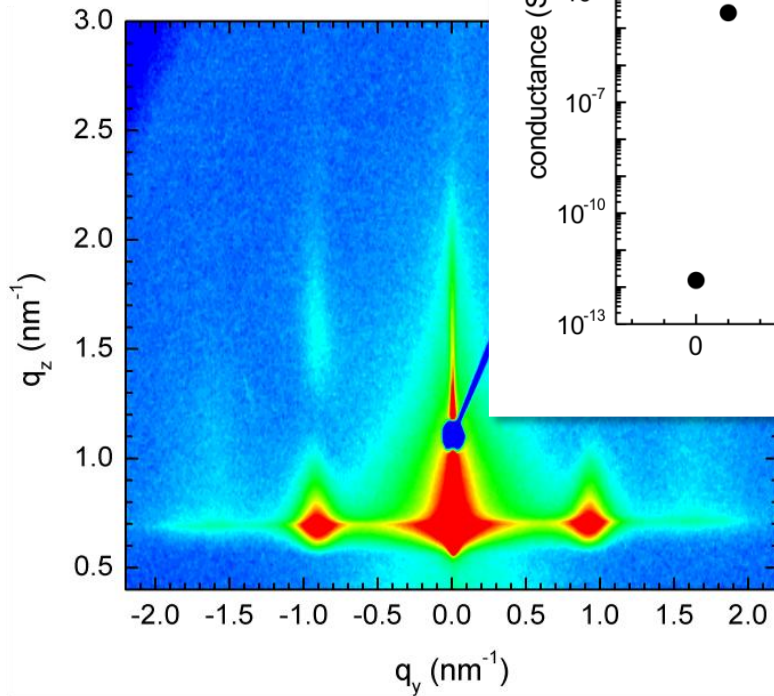


Nanoparticle surfactant:

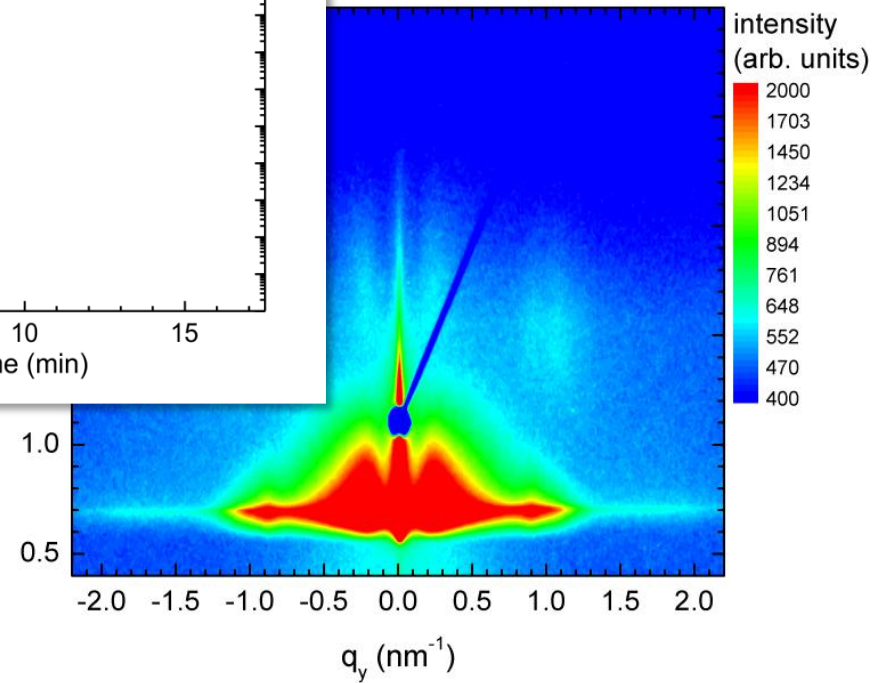
conductivity of Ag nanoparticles after UV exposure



Initial self-assembly

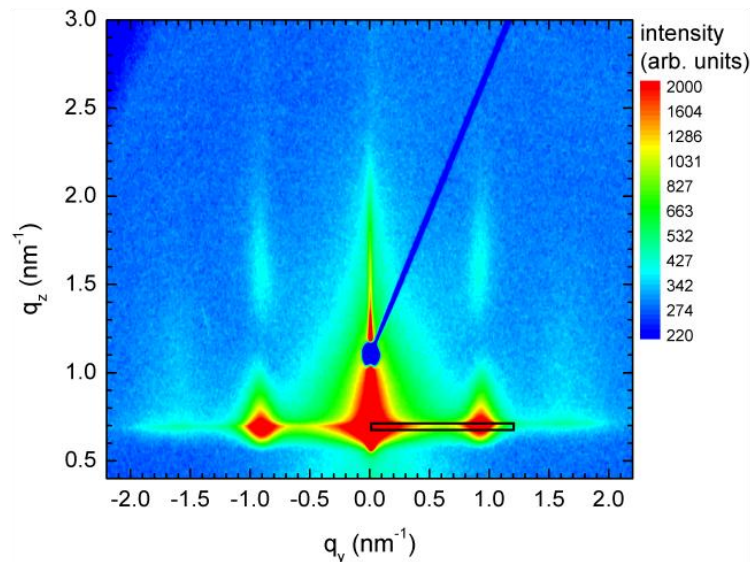


de-assembly state

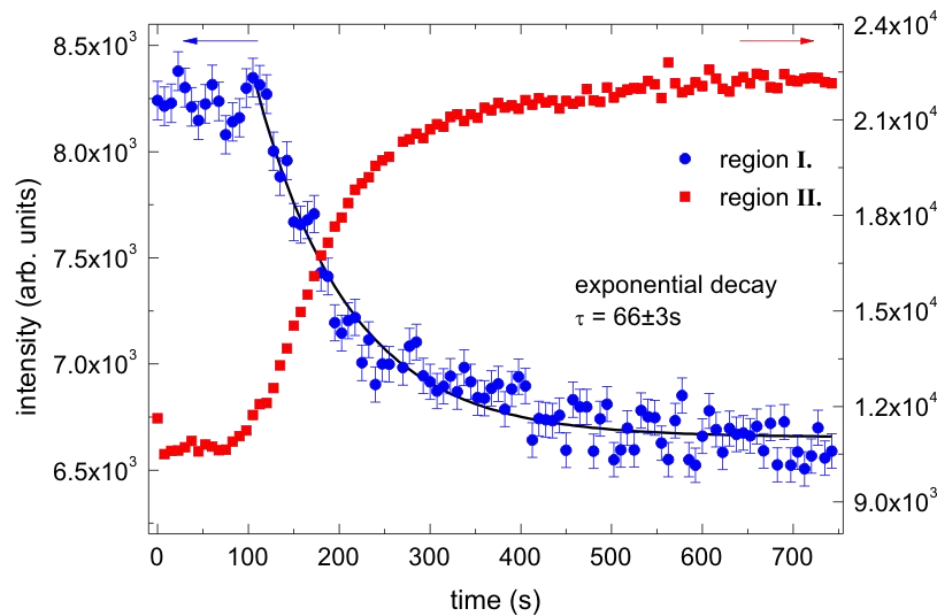
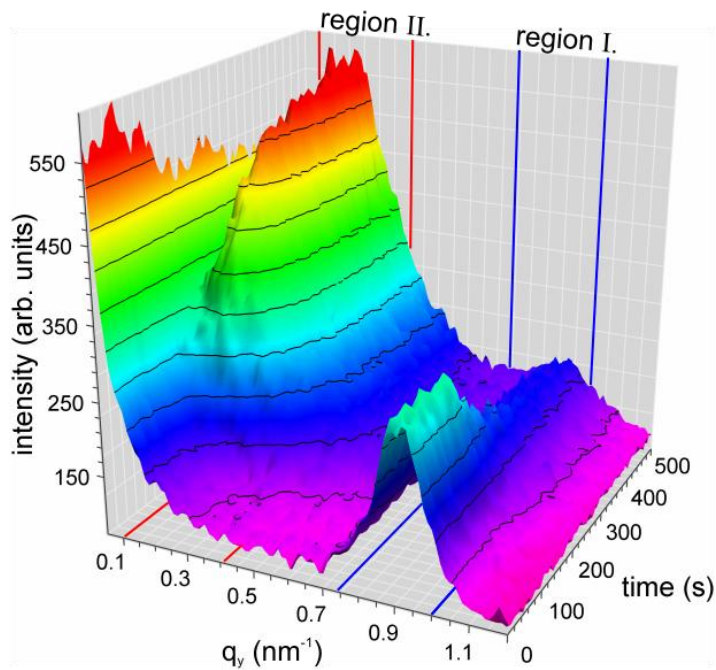
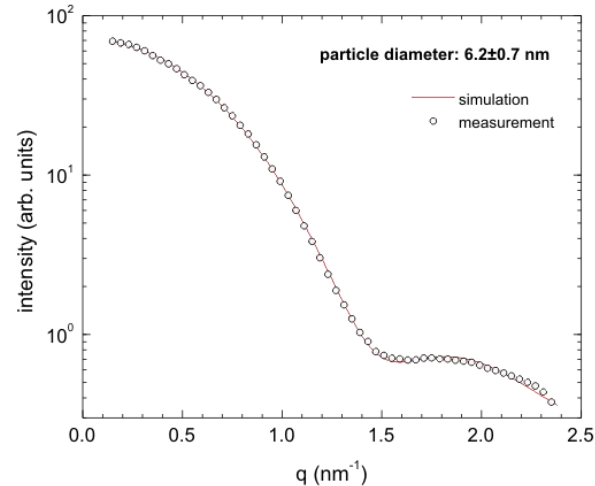


Photoinduced re-assembly of nanoparticles – reciprocal space

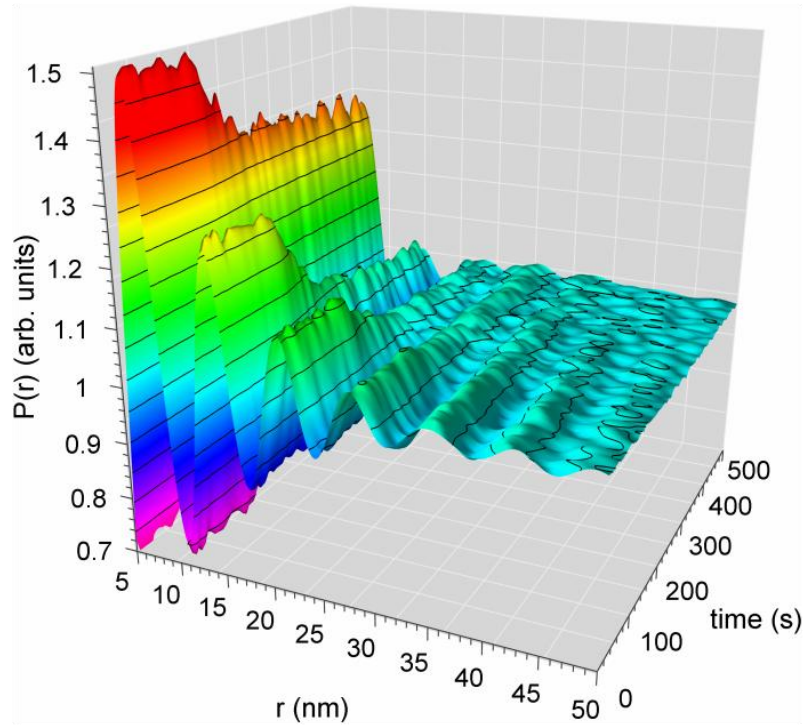
Initial self-assembled state



SAXS - diluted nanoparticle colloid



Photoinduced re-assembly of nanoparticles – object space



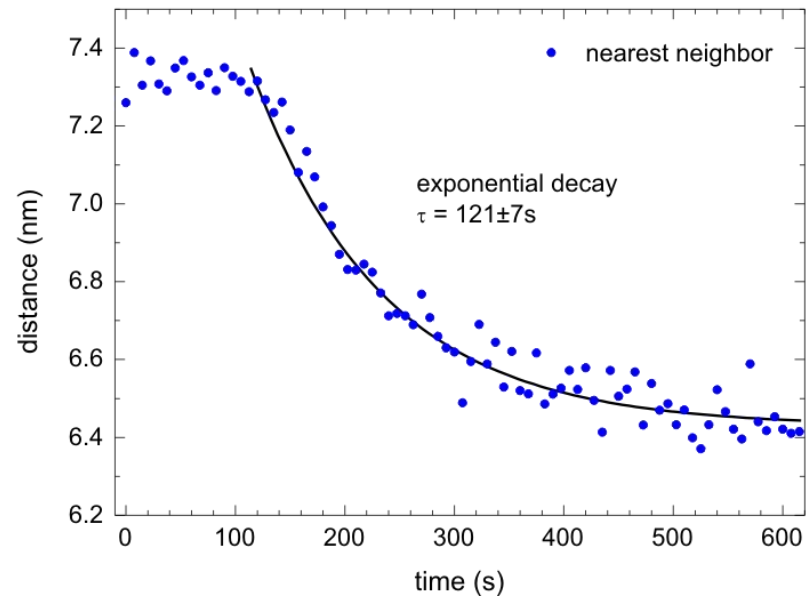
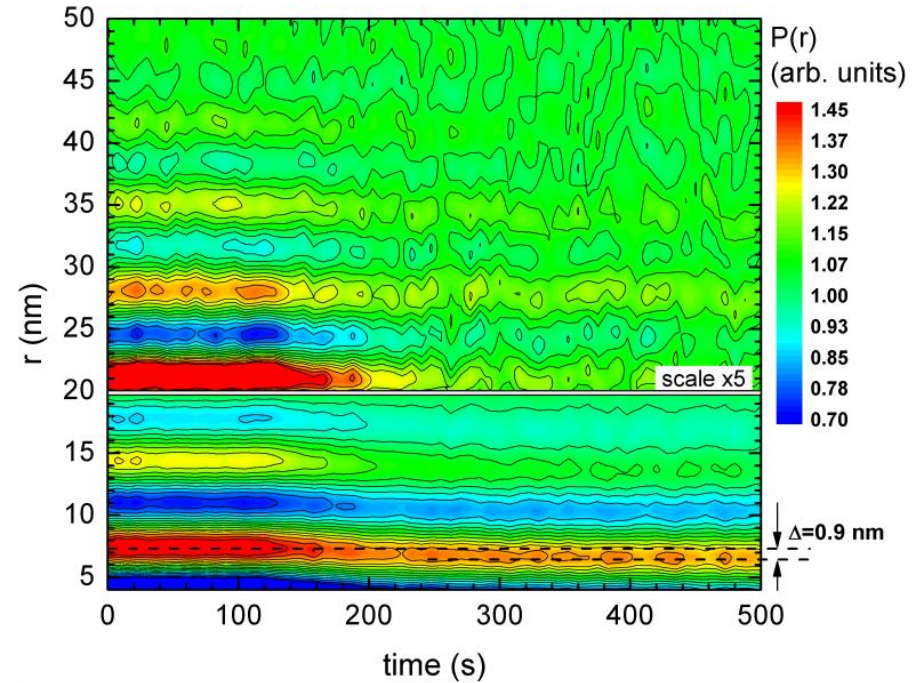
at constant k_z^i, k_z^f ; $q_{\parallel} = q_y$

$|F_s(q_{\parallel})|^2$ - form factor of full sphere

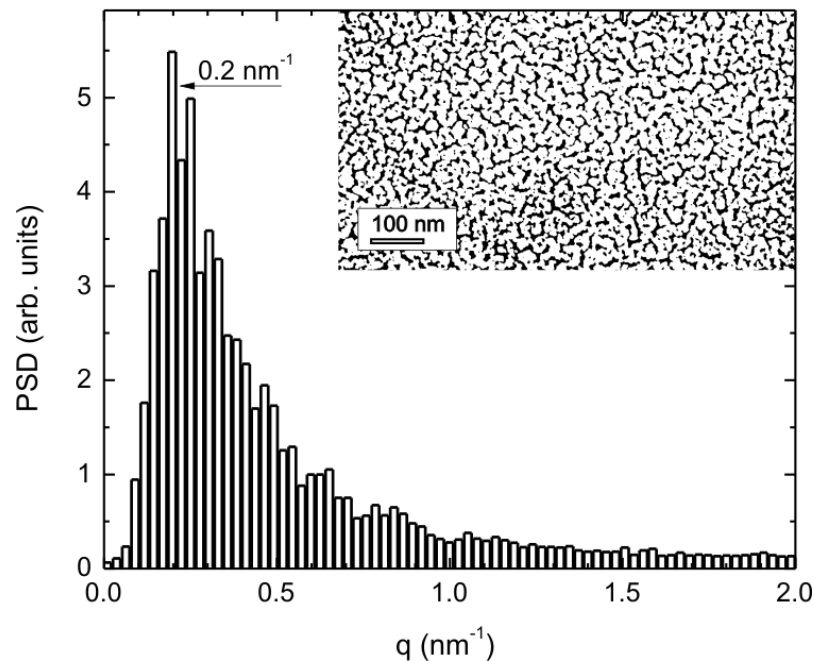
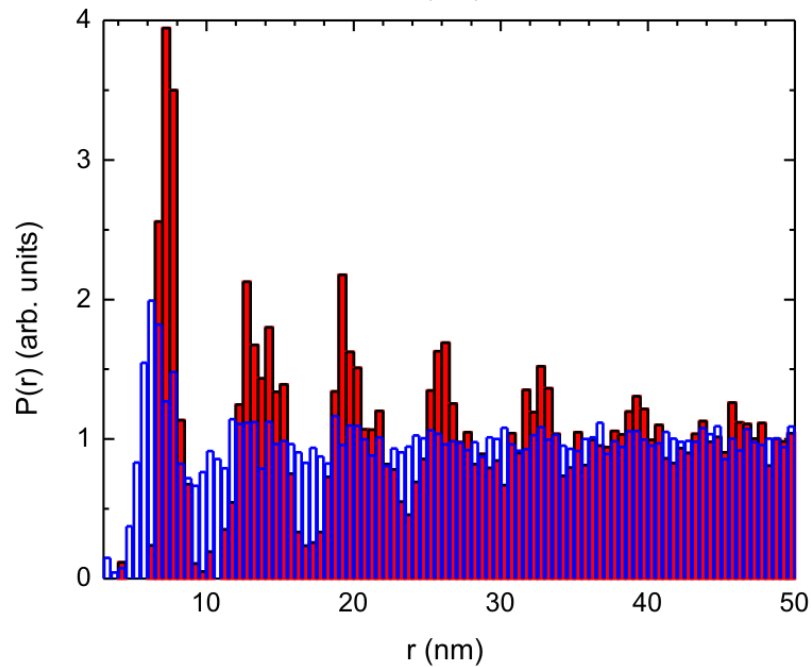
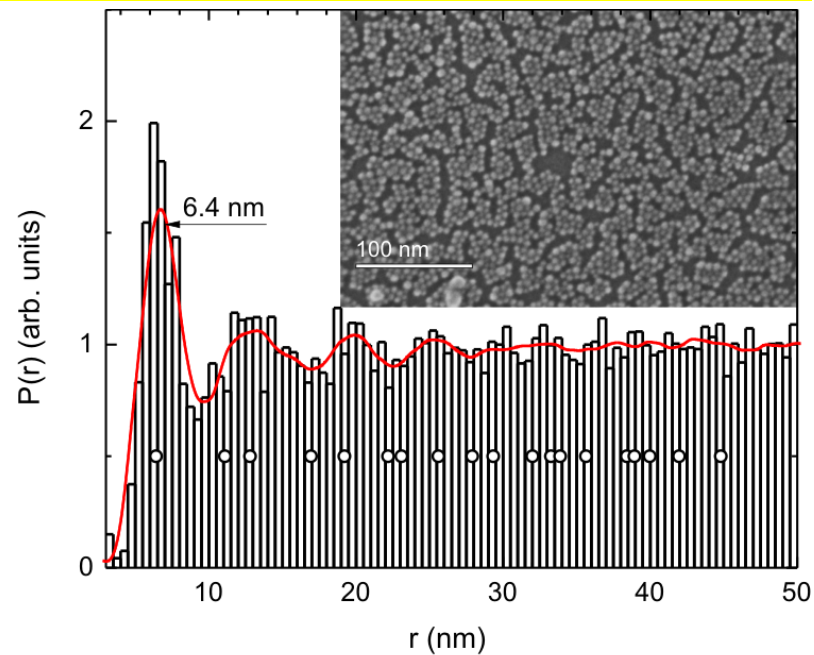
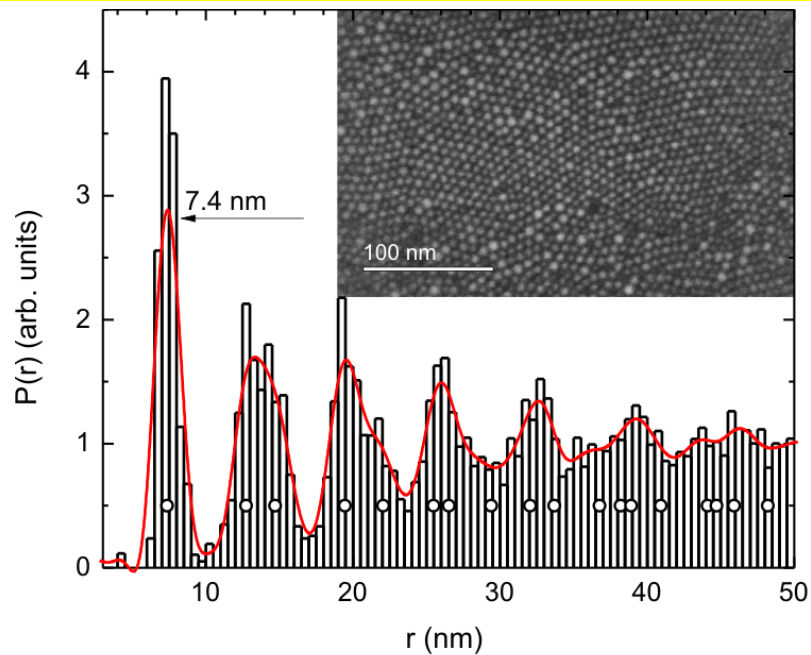
$$|F(q_{\parallel})|^2 = \int_0^{\infty} |F_s(q_{\parallel})|^2 e^{-\frac{(r_0-r)^2}{2\sigma^2}} dr$$

$$I(q_{\parallel}) \sim |F(q_{\parallel})|^2 \cdot S(q_{\parallel})$$

$$g(r_{\parallel}) = 1 + \frac{1}{2\pi\rho_s} \int_0^{\infty} (S(q_{\parallel}) - 1) J_0(q_{\parallel} r_{\parallel}) q_{\parallel} dq_{\parallel}$$

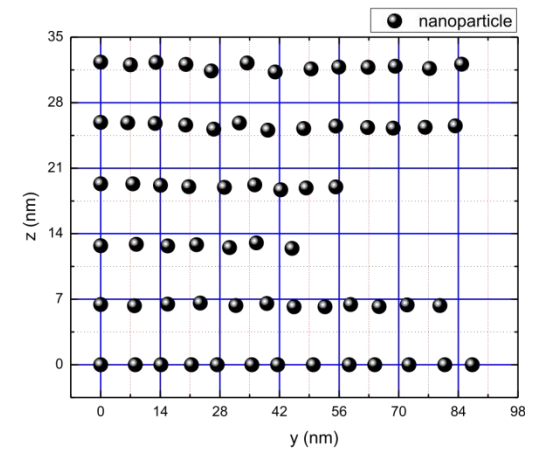
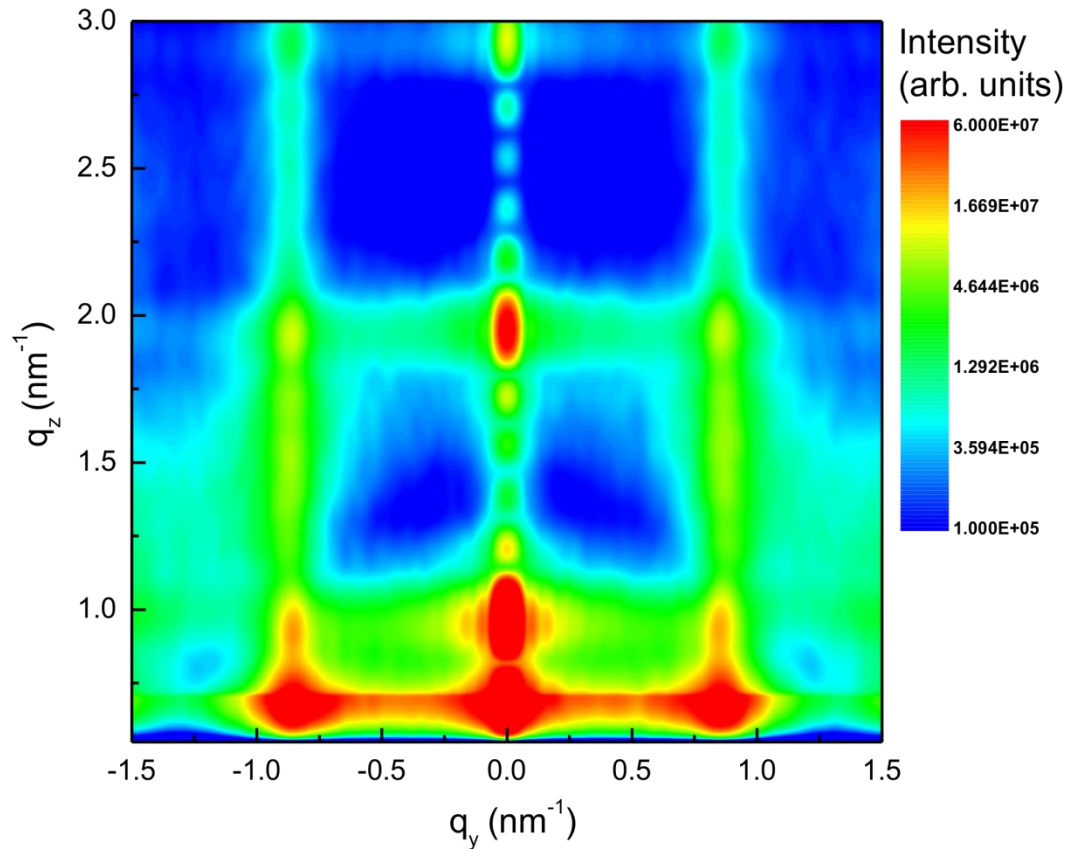


Pair correlation function of initial and final assembly - SEM



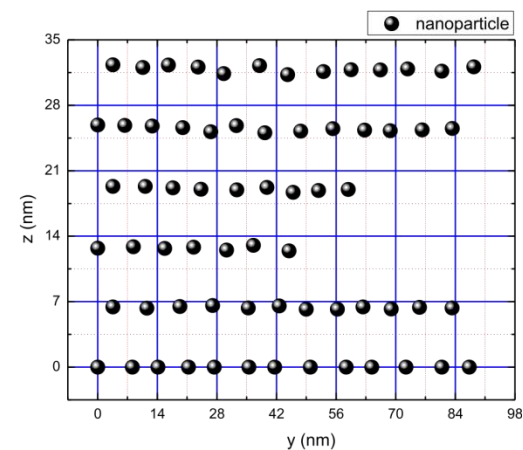
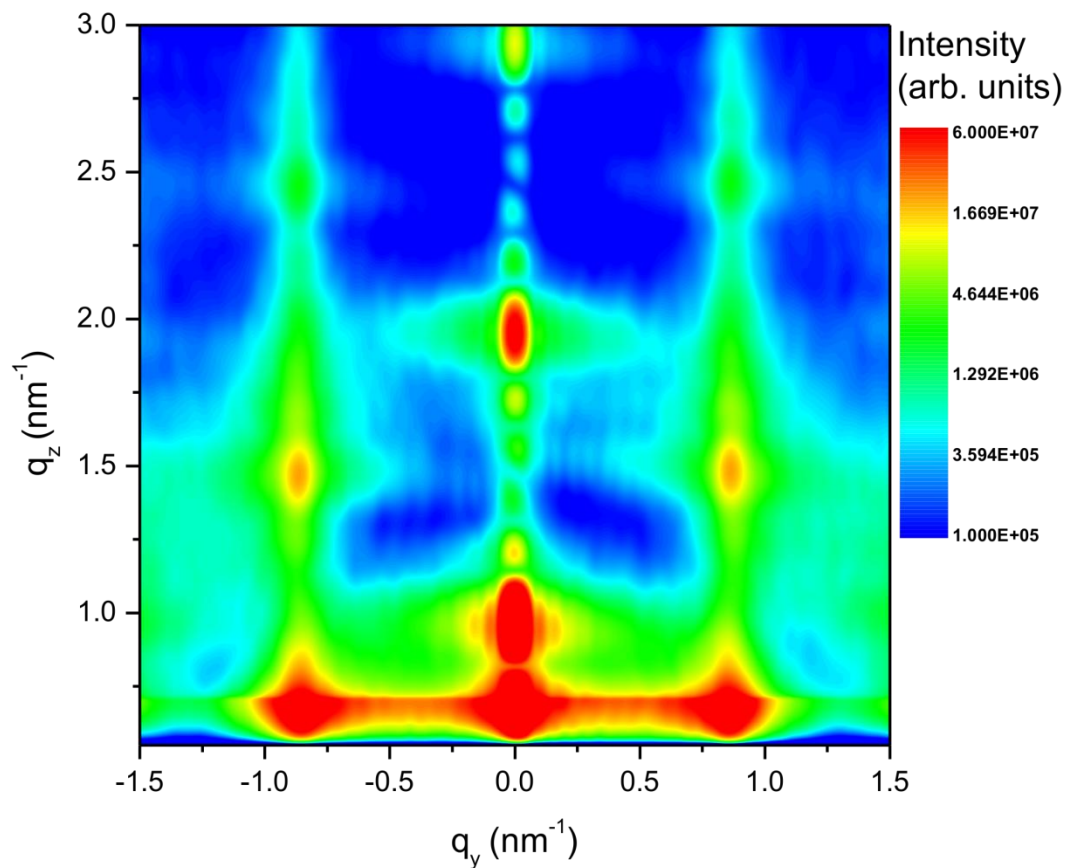
Nanoparticle multilayers and the role vertical correlation

No shift between layers



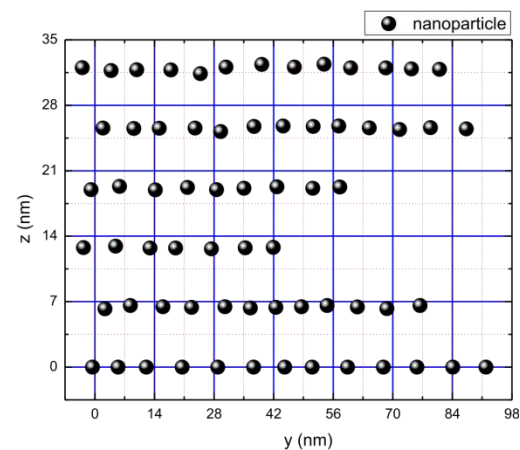
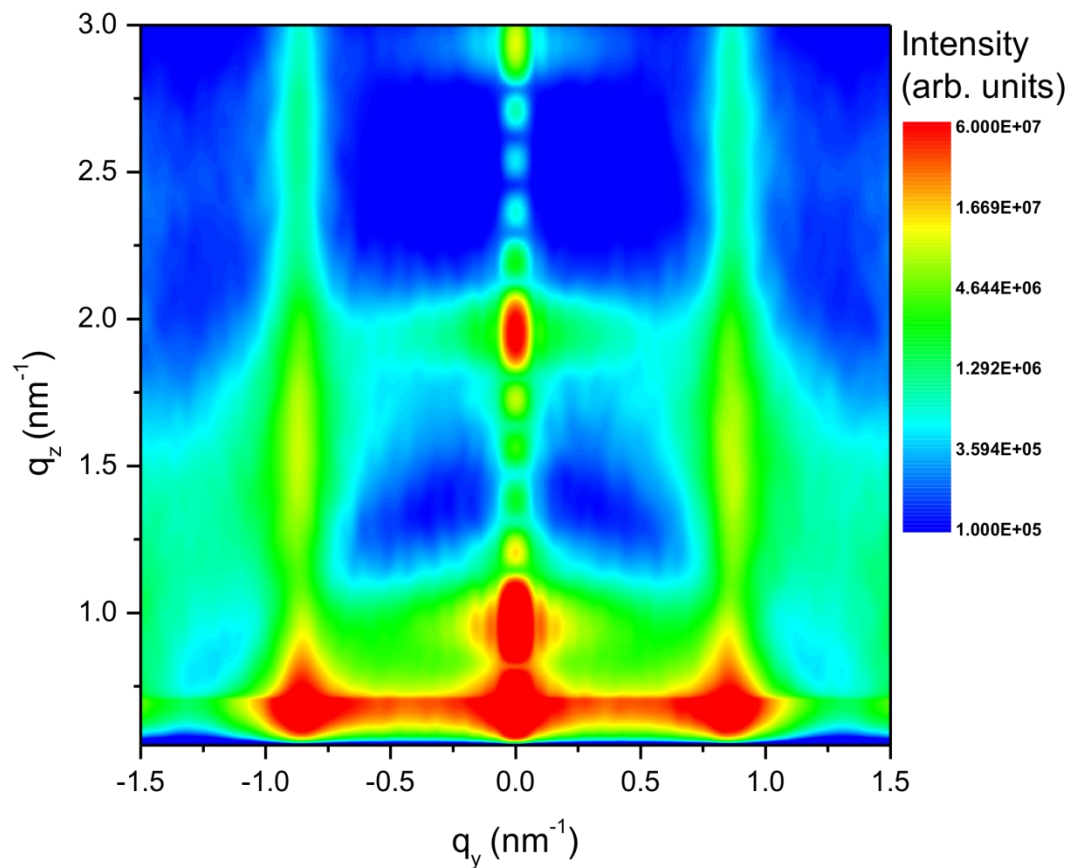
Nanoparticle multilayers and the role vertical correlation

Alternate shift between layers



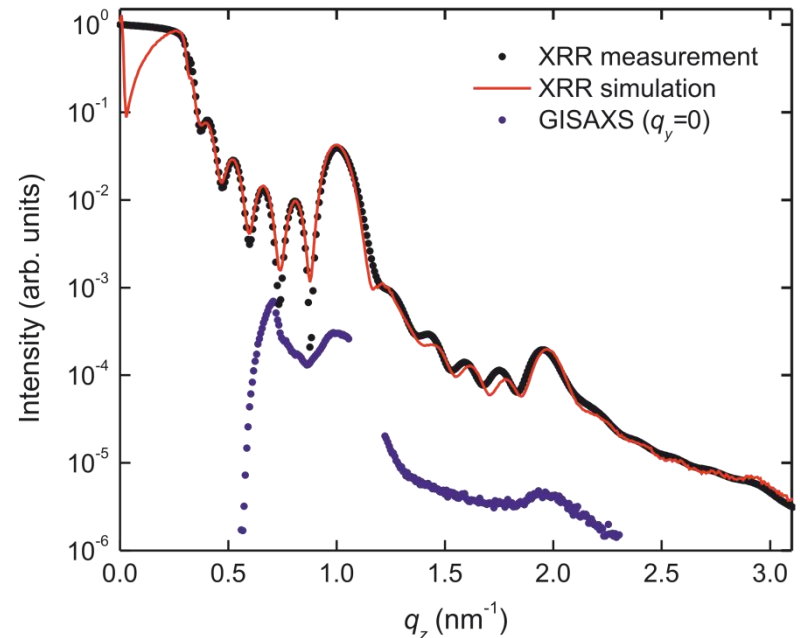
Nanoparticle multilayers and the role vertical correlation

Uniform random shift between layers

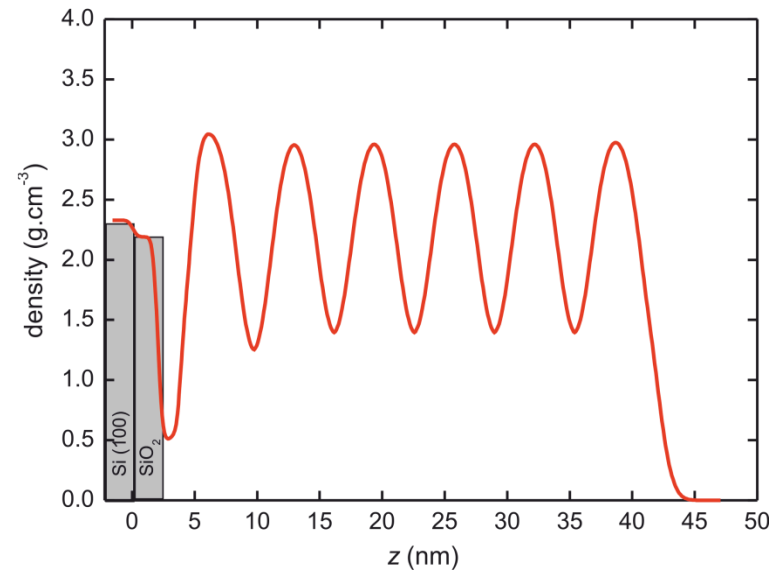


Nanoparticle multilayers / vertically uncorrelated system

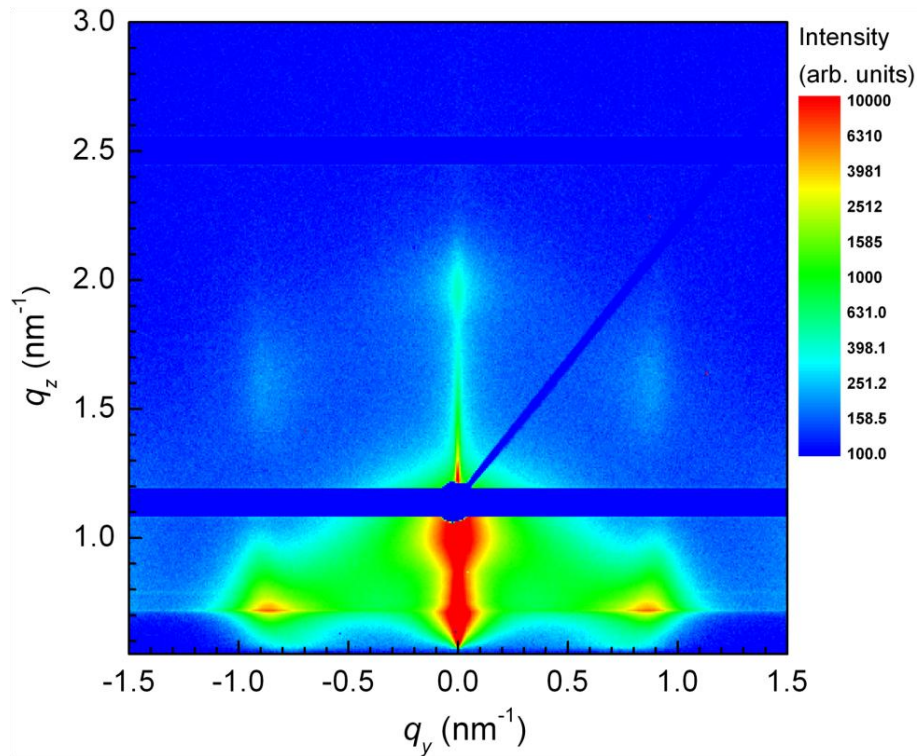
XRR measurement of 6 layers of nanoparticles



Density profile used for XRR simulation



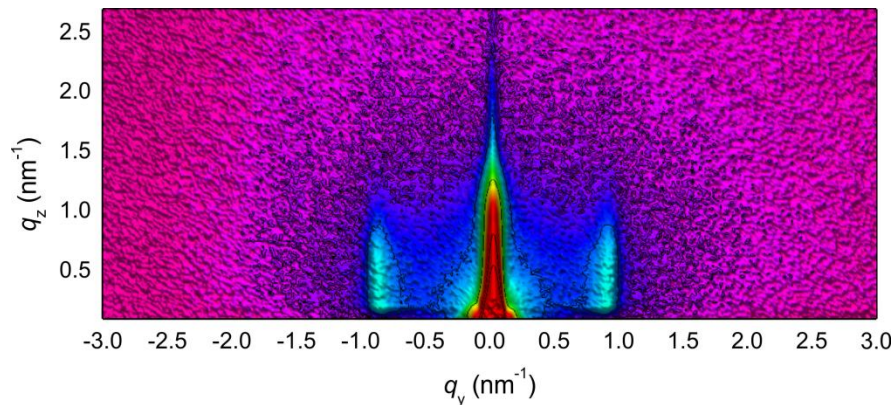
Measured GISAXS pattern for 6 uncorrelated layers



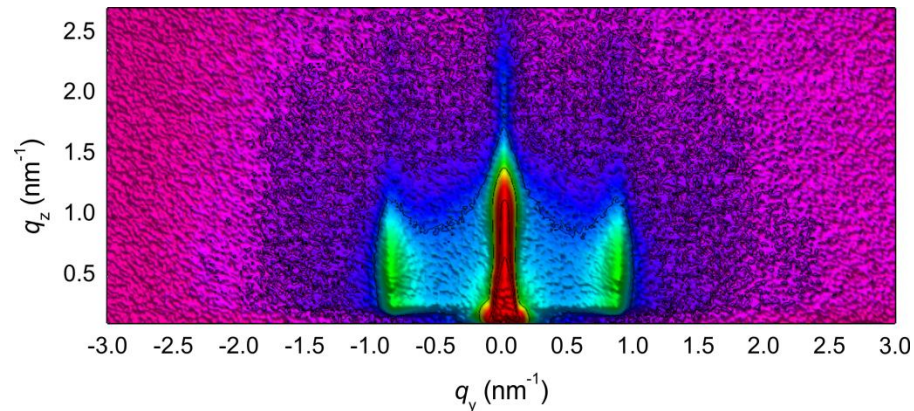
Nanoparticle multilayers / vertically correlated system

Measured GISAXS pattern for different surface pressures at Langmuir-Blodgett trough

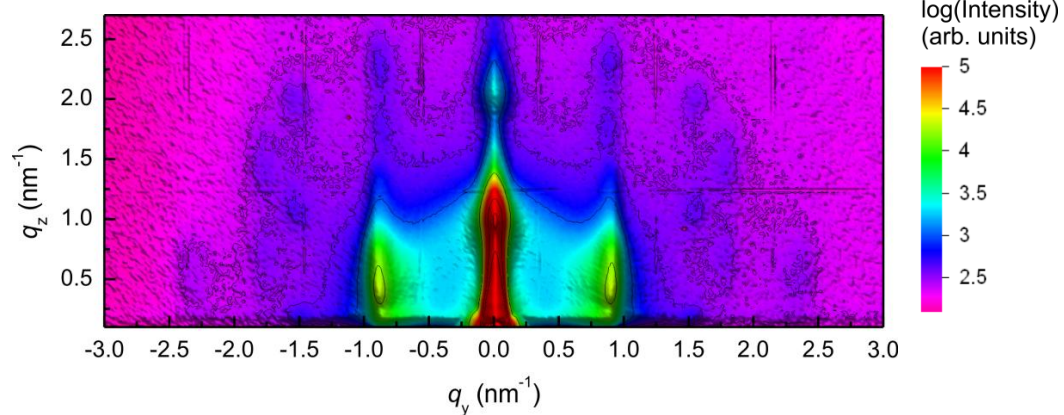
16 mN/m



20 mN/m



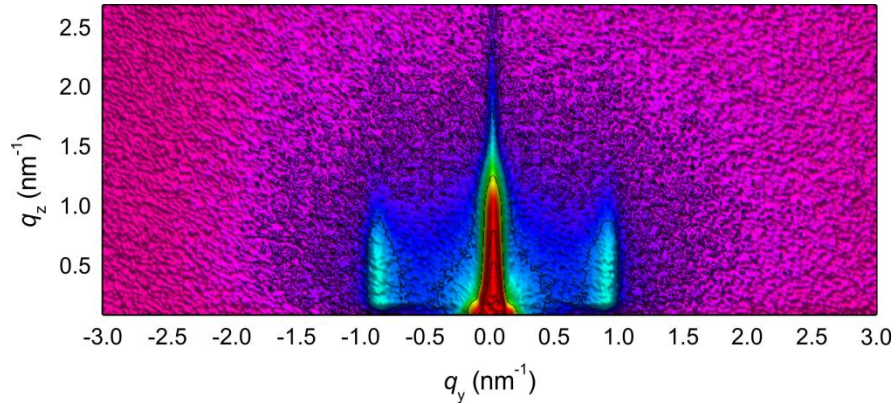
26 mN/m



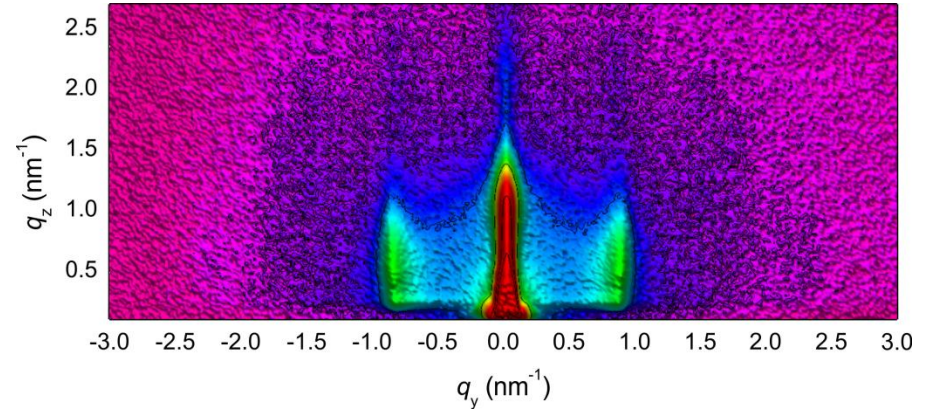
Nanoparticle multilayers / vertically correlated system

Measured GISAXS pattern for different surface pressures at Langmuir-Blodgett trough

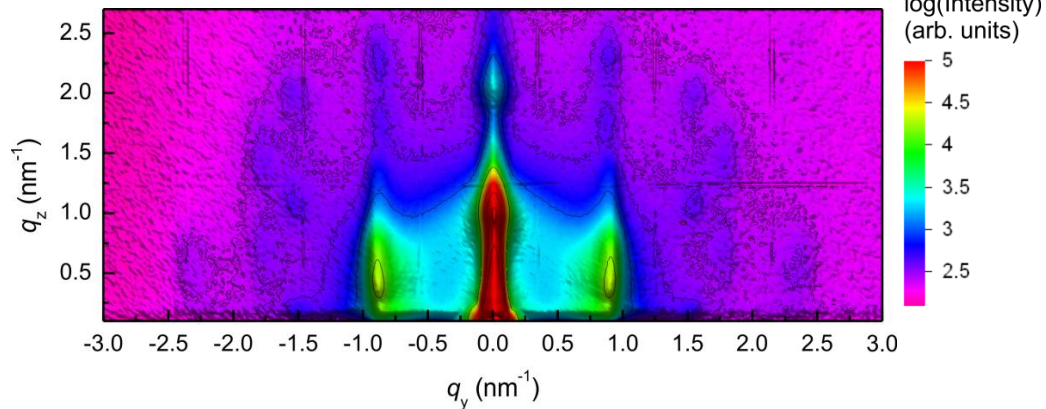
16 mN/m



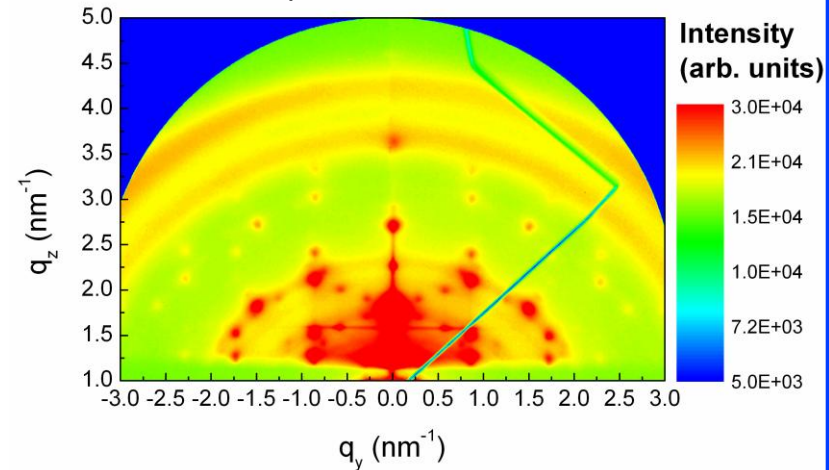
20 mN/m



26 mN/m

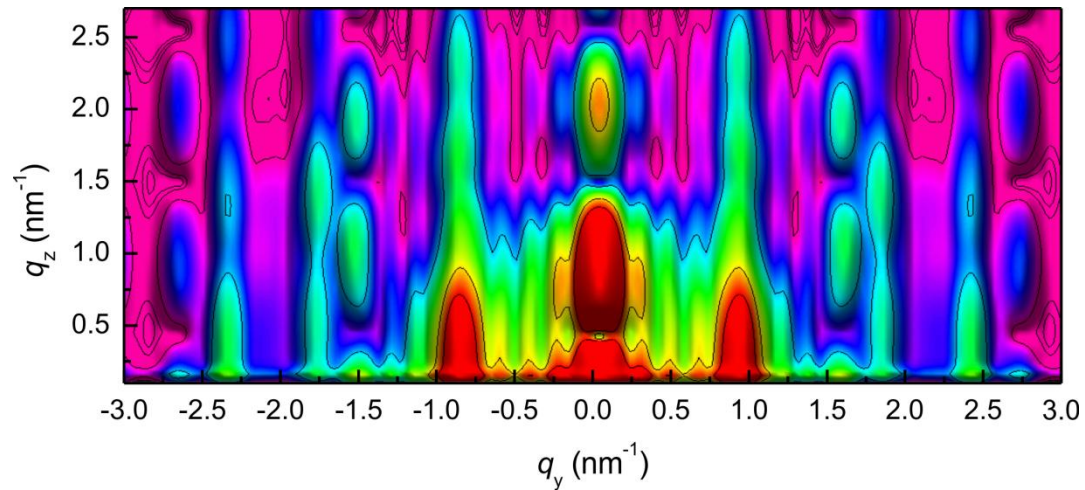


dropcast method

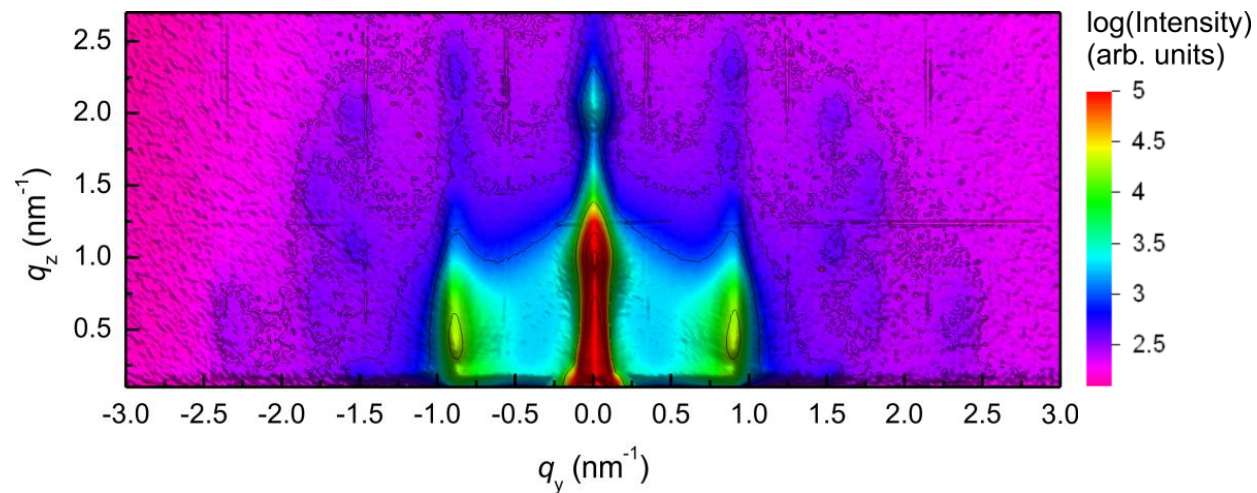


Nanoparticle multilayers / vertically correlated system

GISAXS simulation (2 monolayers)

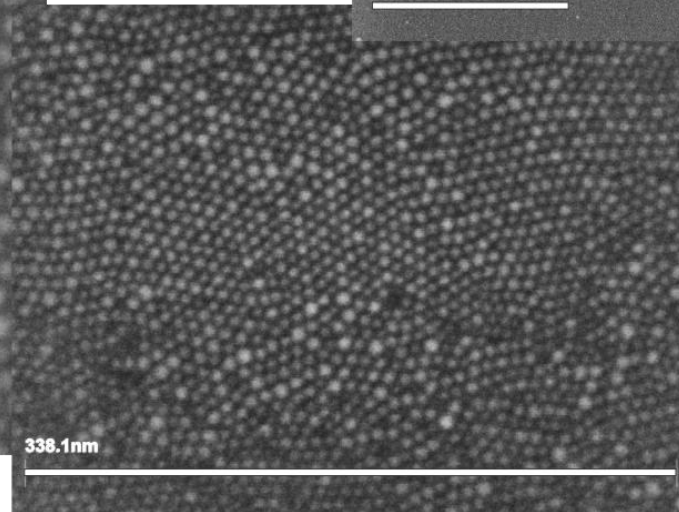
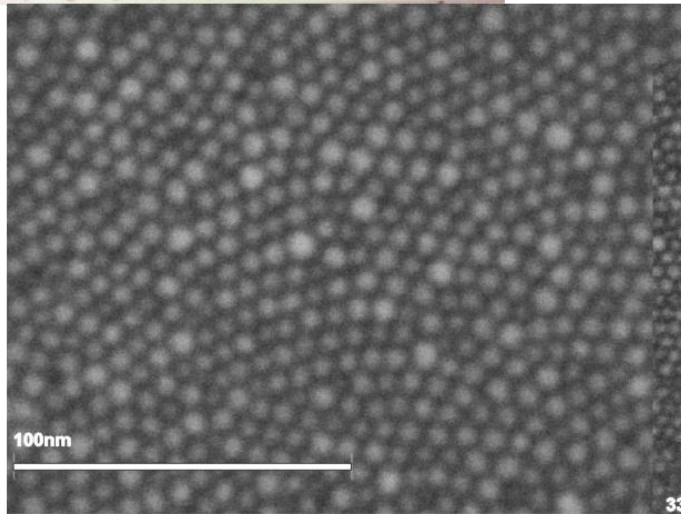
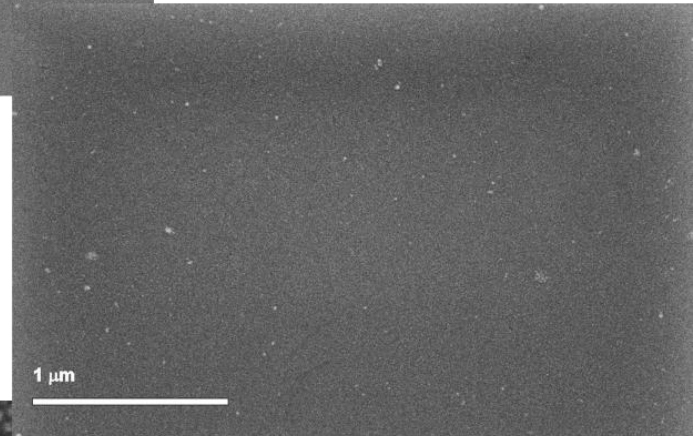
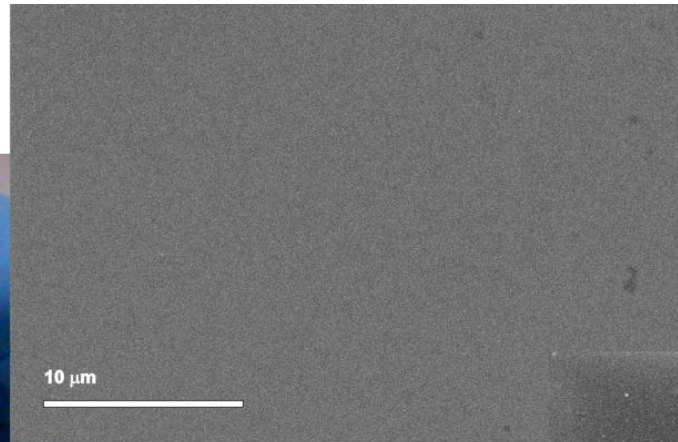
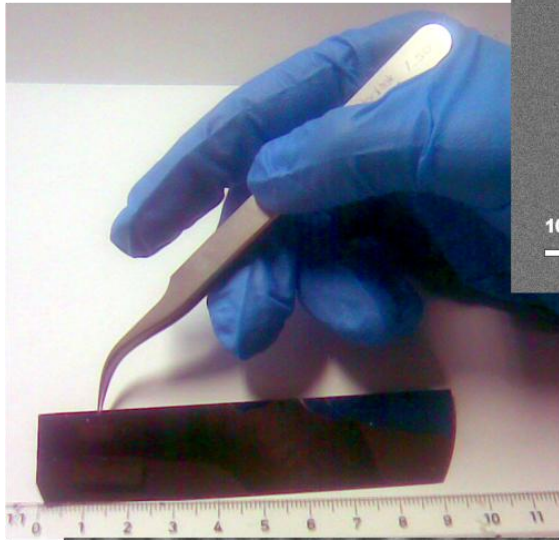


GISAXS measurement



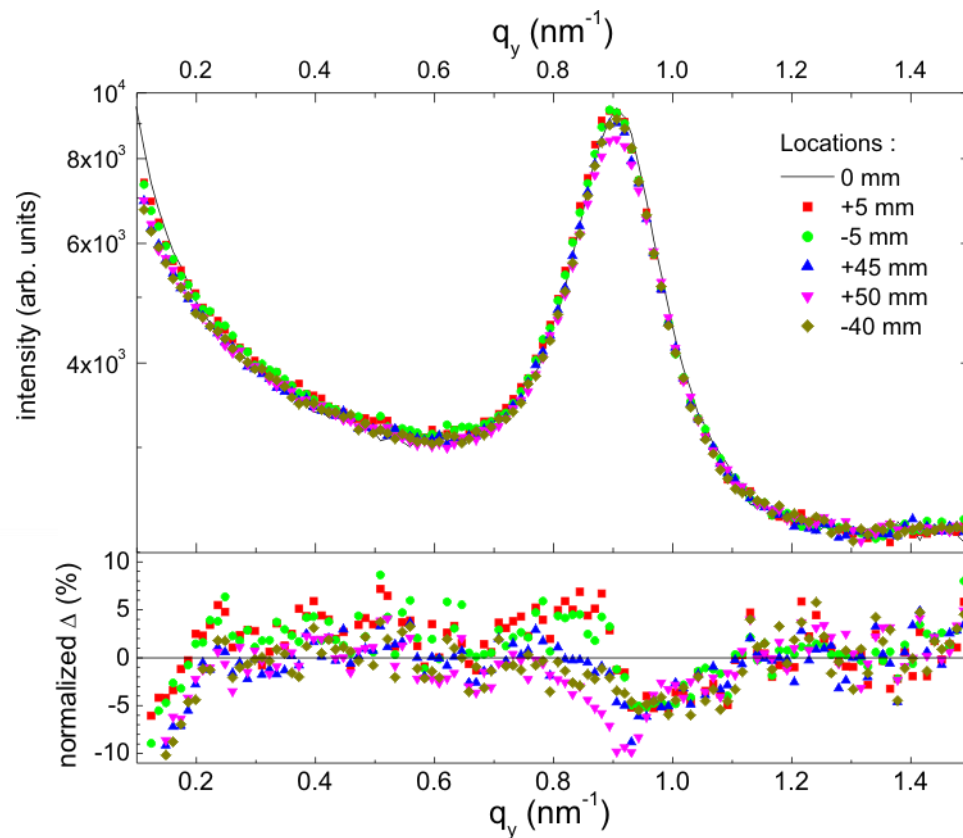
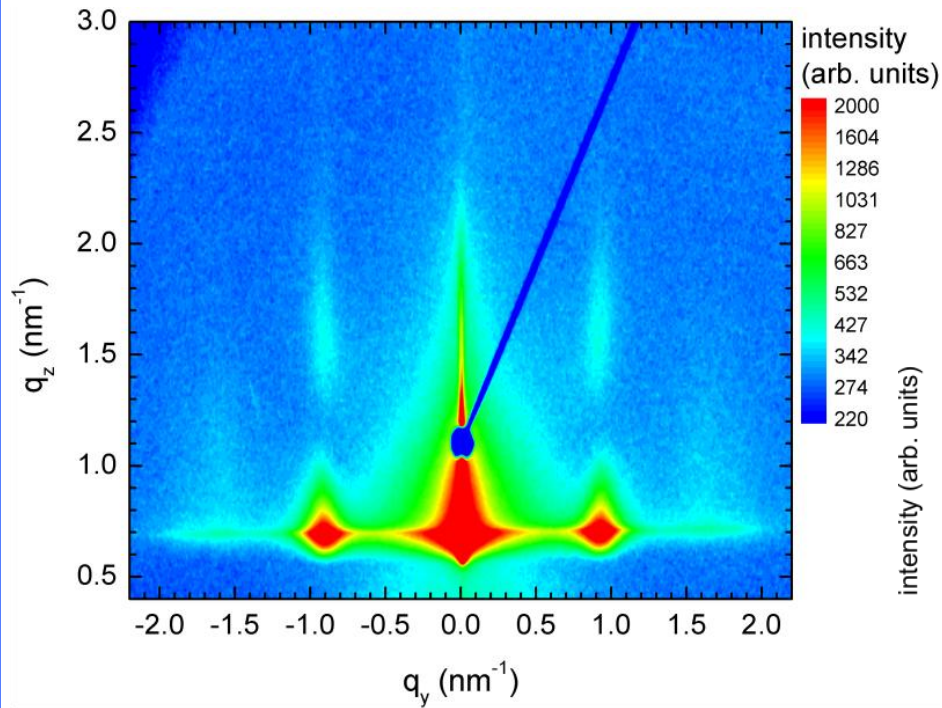
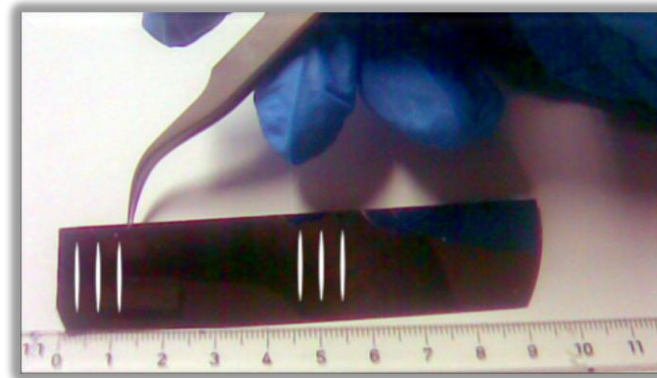
GISAXS in applied nanoparticle science

Homogenous large-scale nanoparticle deposition



GISAXS in applied nanoparticle science

Homogenous large-scale nanoparticle deposition



GISAXS in applied nanoparticle science / solar cells

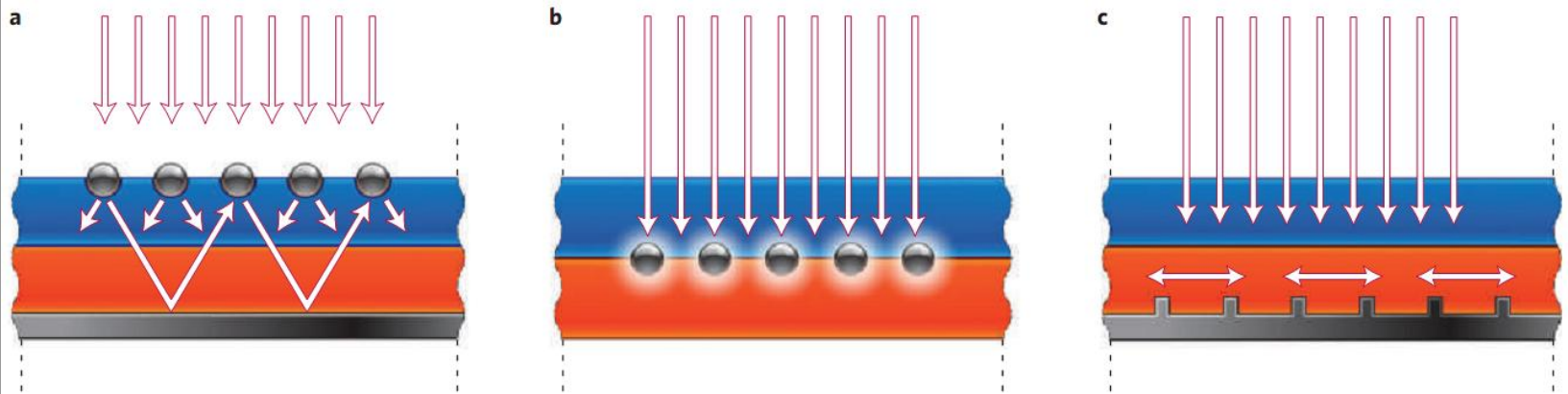
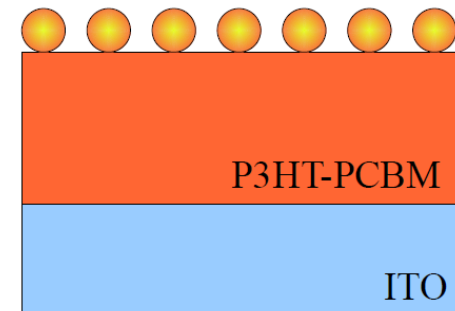
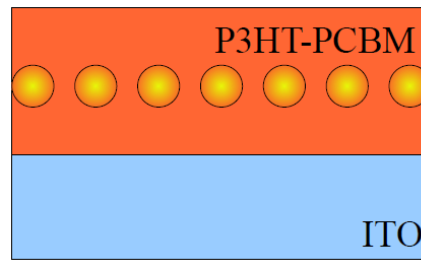
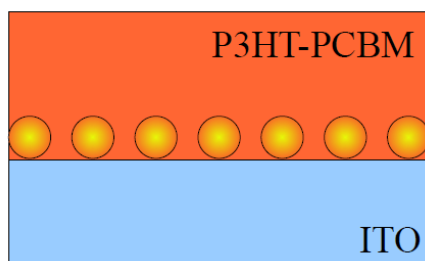


Figure 2 | Plasmonic light-trapping geometries for thin-film solar cells. **a**, Light trapping by scattering from metal nanoparticles at the surface of the solar cell. Light is preferentially scattered and trapped into the semiconductor thin film by multiple and high-angle scattering, causing an increase in the effective optical path length in the cell. **b**, Light trapping by the excitation of localized surface plasmons in metal nanoparticles embedded in the semiconductor. The excited particles' near-field causes the creation of electron-hole pairs in the semiconductor. **c**, Light trapping by the excitation of surface plasmon polaritons at the metal/semiconductor interface. A corrugated metal back surface couples light to surface plasmon polariton or photonic modes that propagate in the plane of the semiconductor layer.

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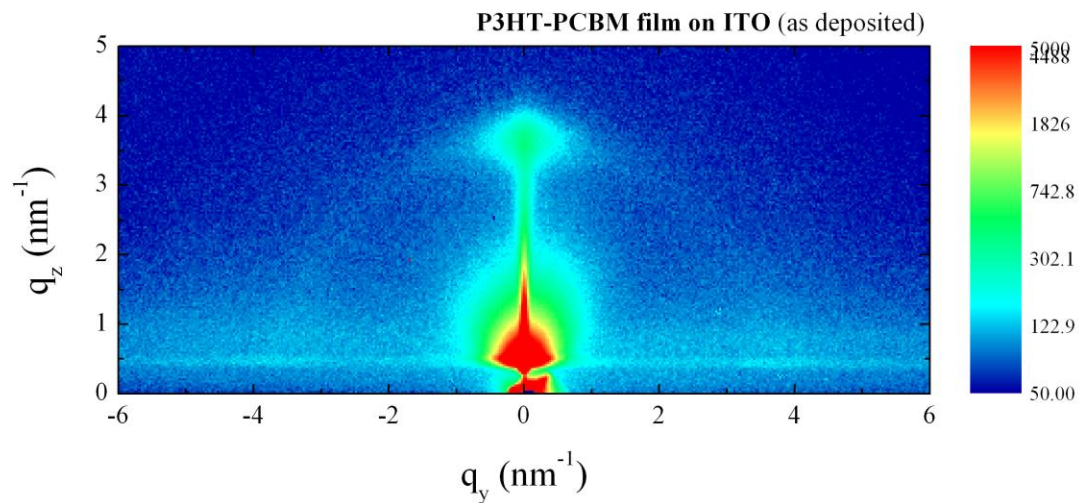
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Ag nanoparticle inclusion into the polymer solar cells

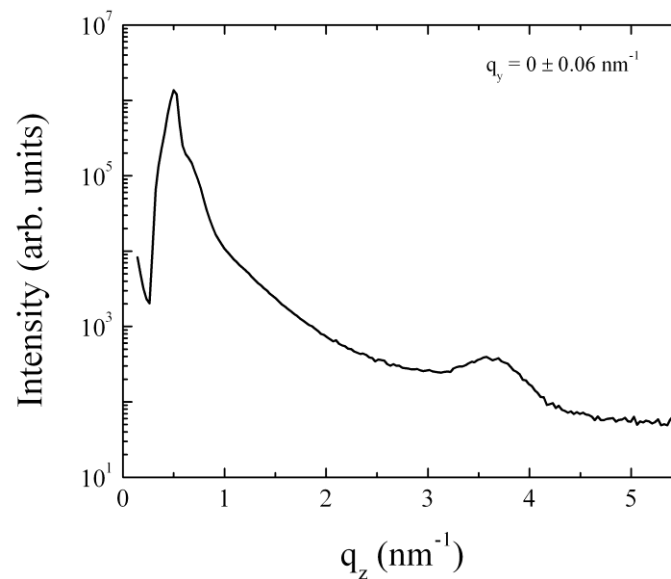
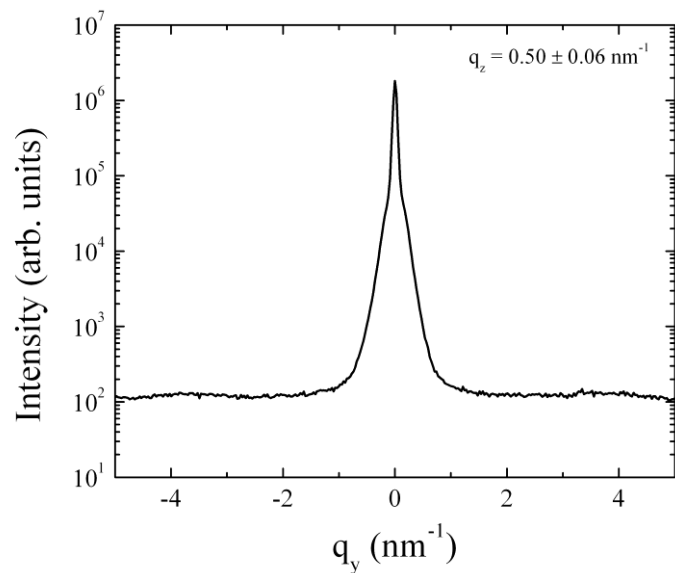


GISAXS in applied nanoparticle science / solar cells

Ag nanoparticle inclusion into the polymer solar cells

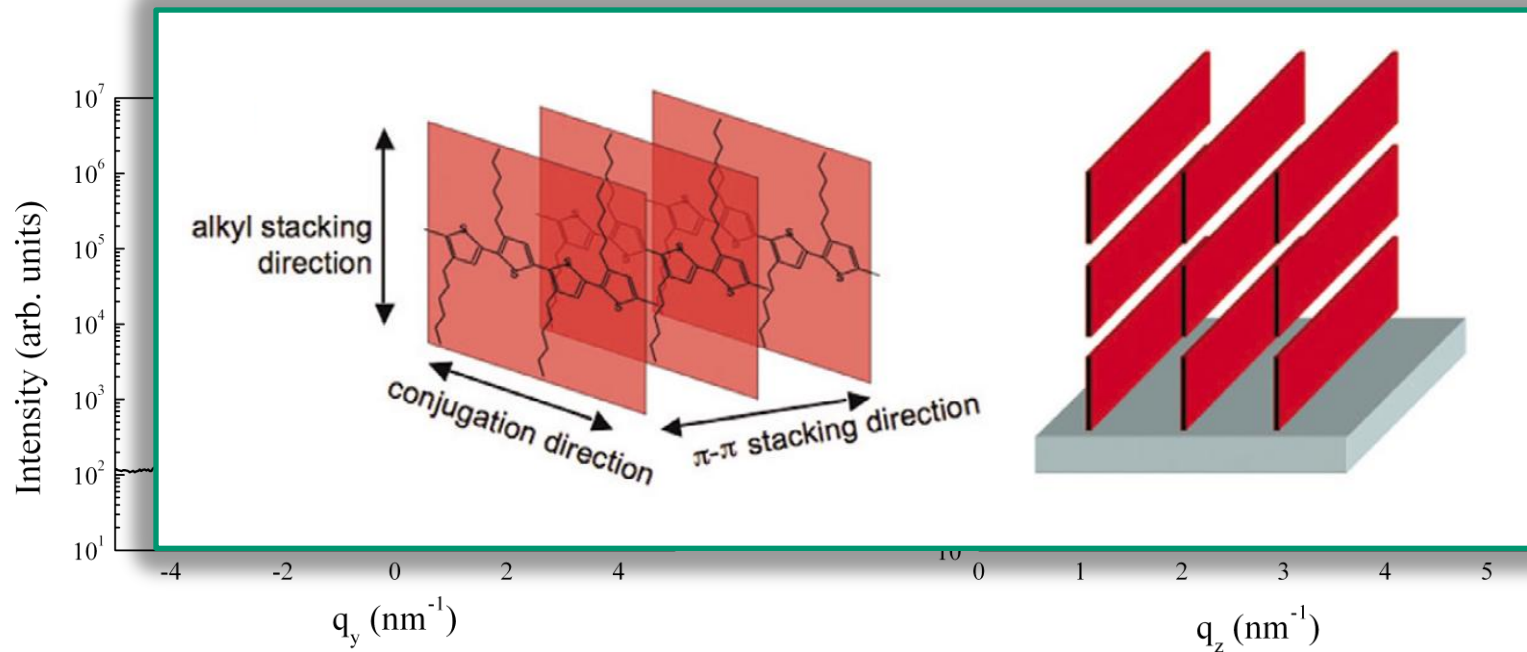
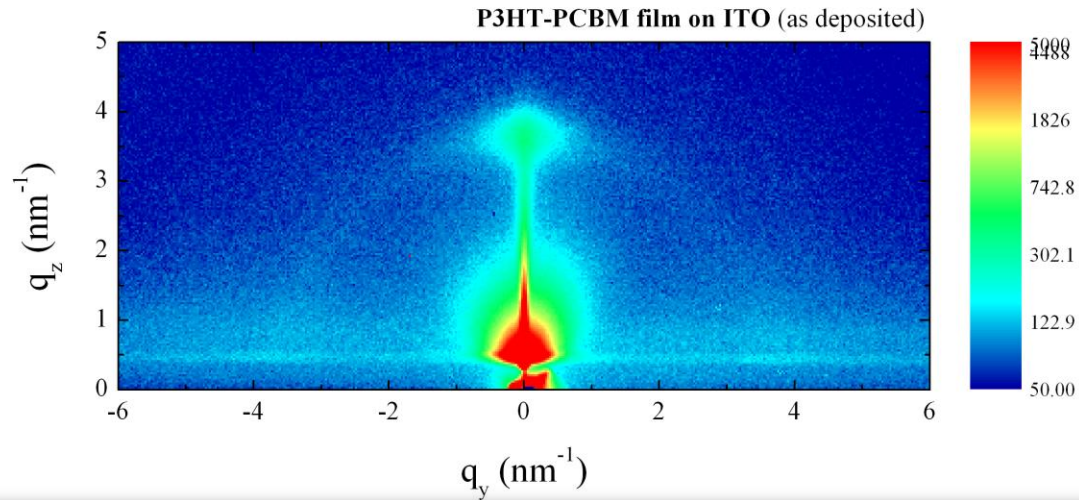


Molecular separation: **1.7 nm** (3.65 nm^{-1})



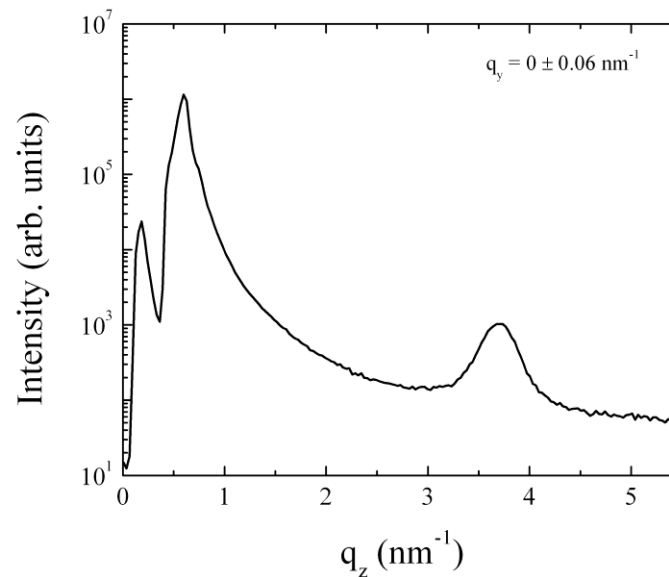
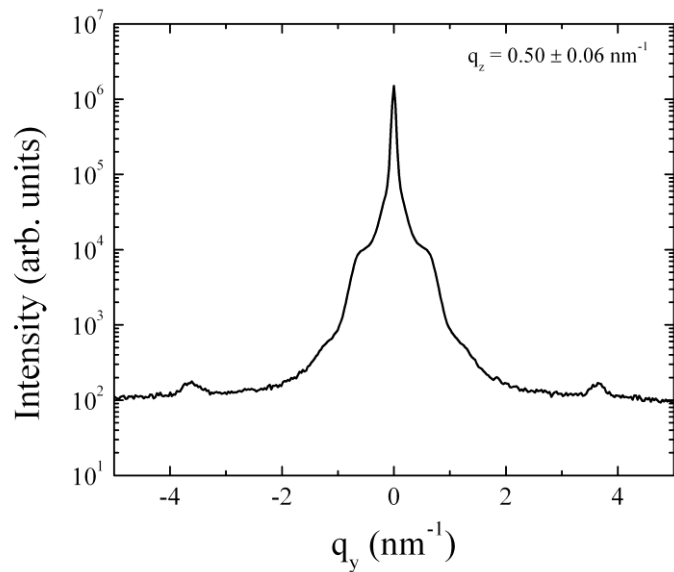
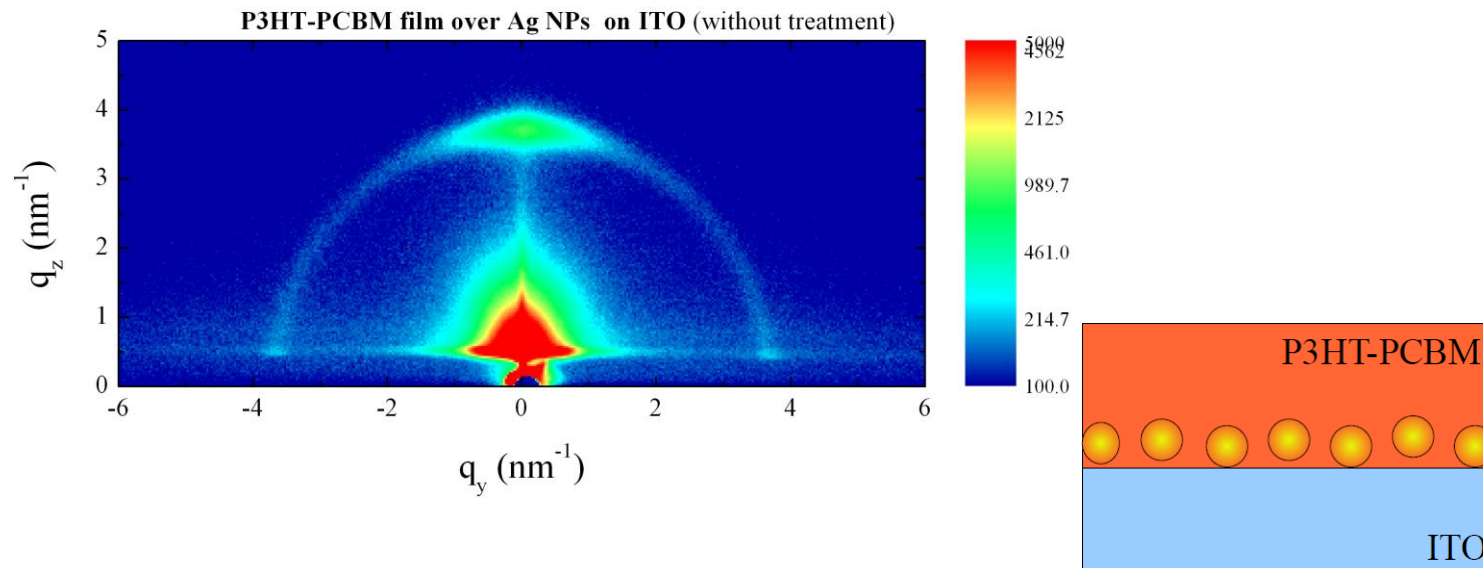
GISAXS in applied nanoparticle science / solar cells

Ag nanoparticle inclusion into the polymer solar cells



GISAXS in applied nanoparticle science / solar cells

Buried Ag nanoparticle template at the ITO/active layer interface



SAXS in applied nanoparticle science / strain gauges

Strain gauge sensors based on nanoparticle assemblies

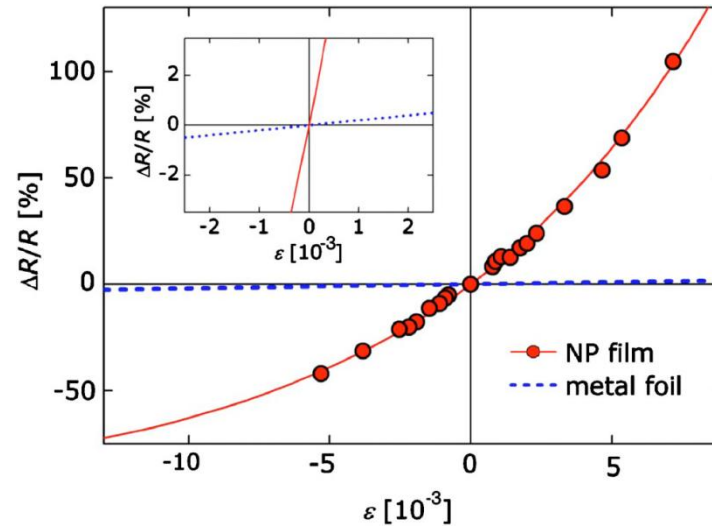
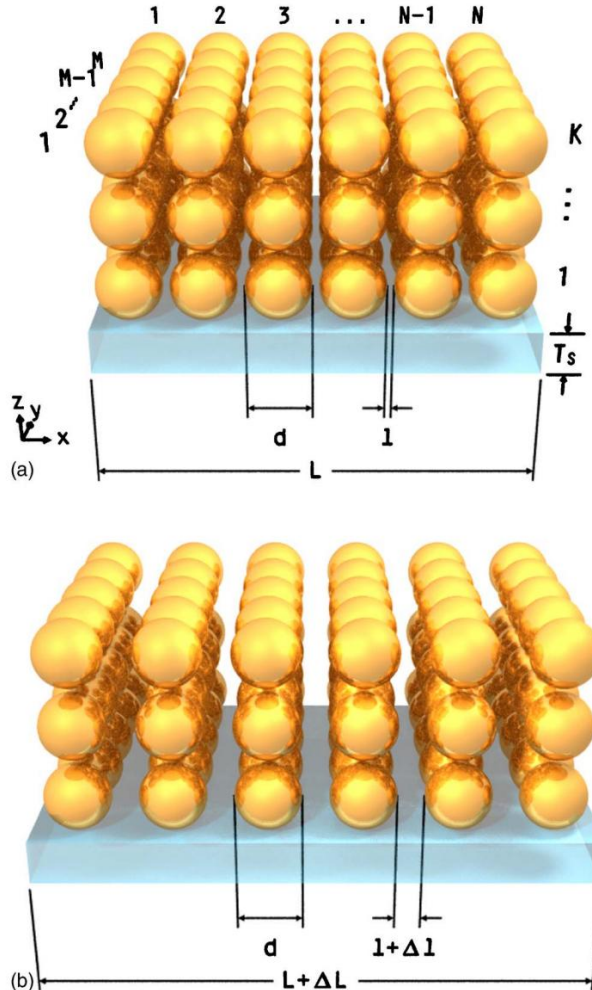
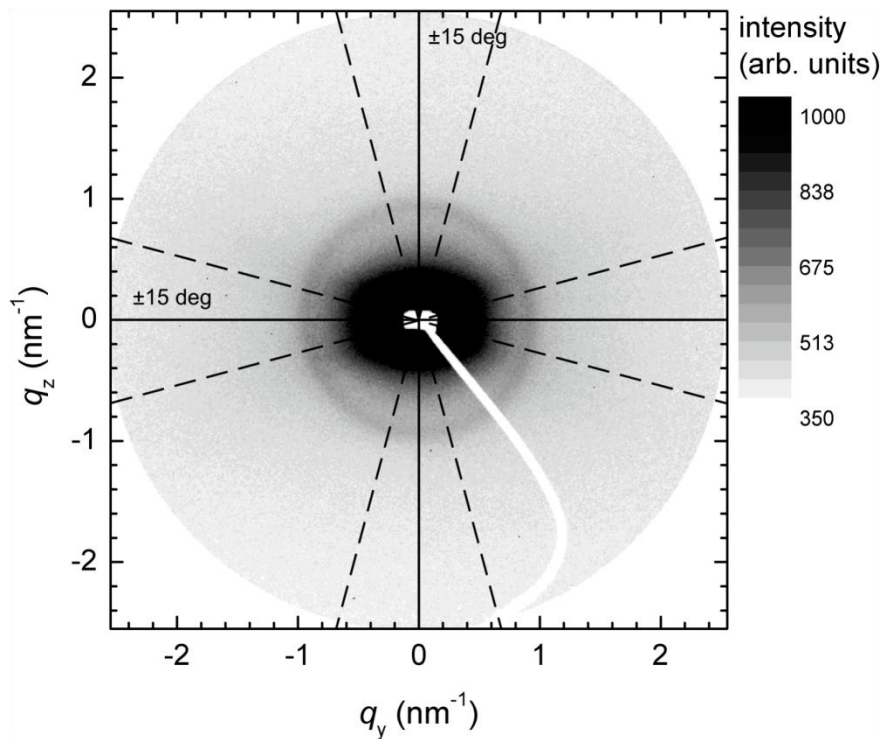
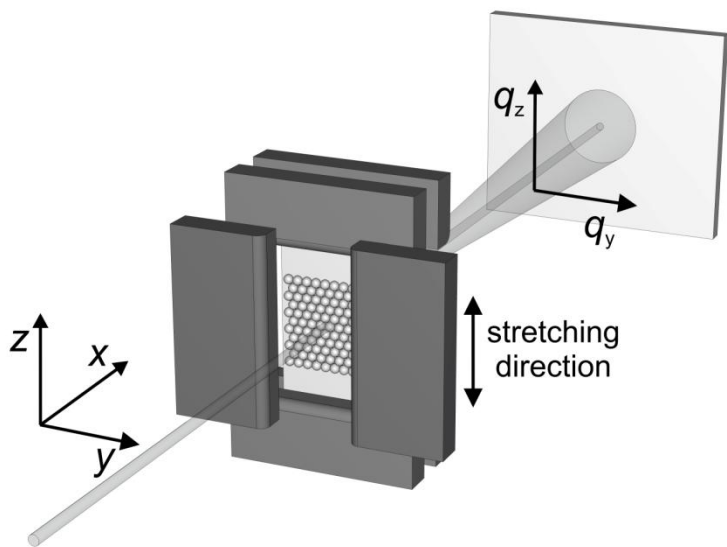


FIG. 1. (Color online) Schematic illustration of the geometry of the NP film. When the unstrained film (a) is subjected to a mechanical stress along the x direction, the overall film length L changes by ΔL (b). In our model, this strain is predominantly caused by changes in the interparticle separation gap l .

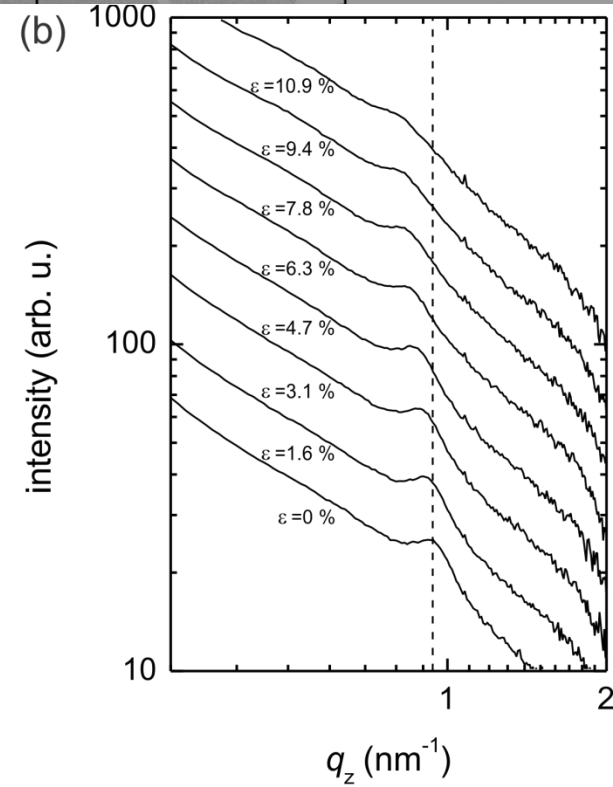
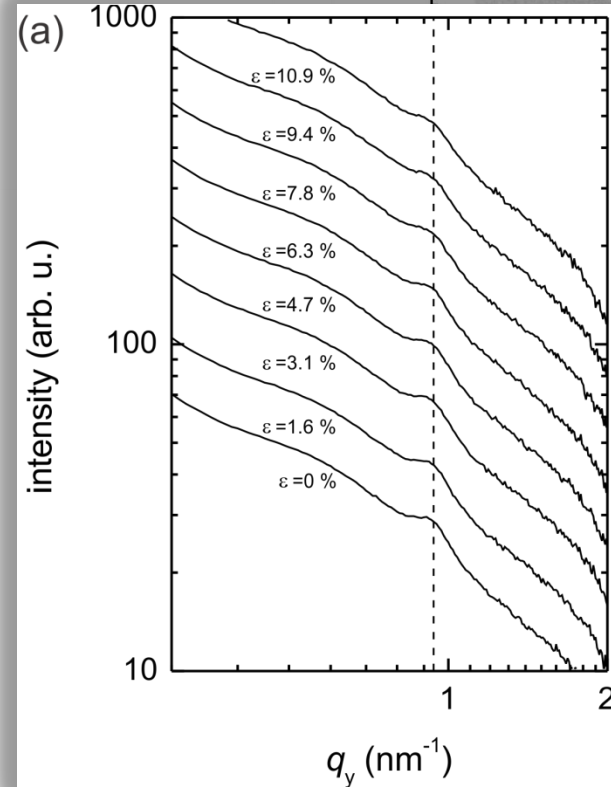
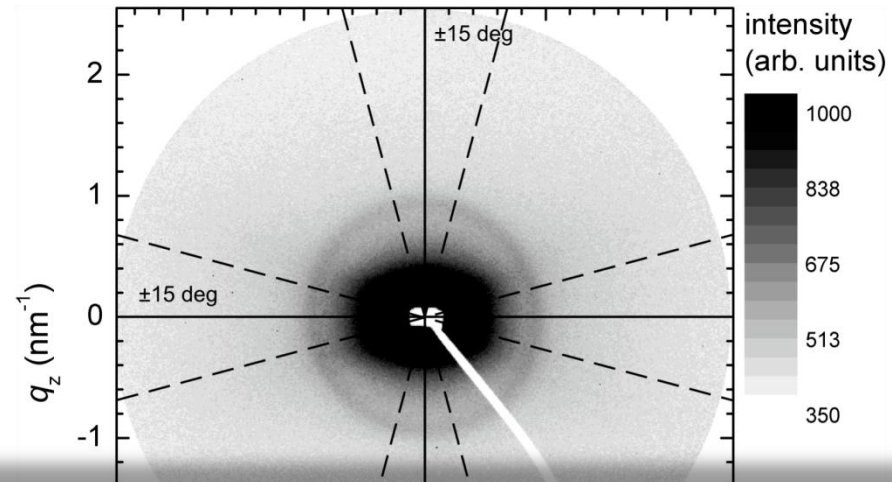
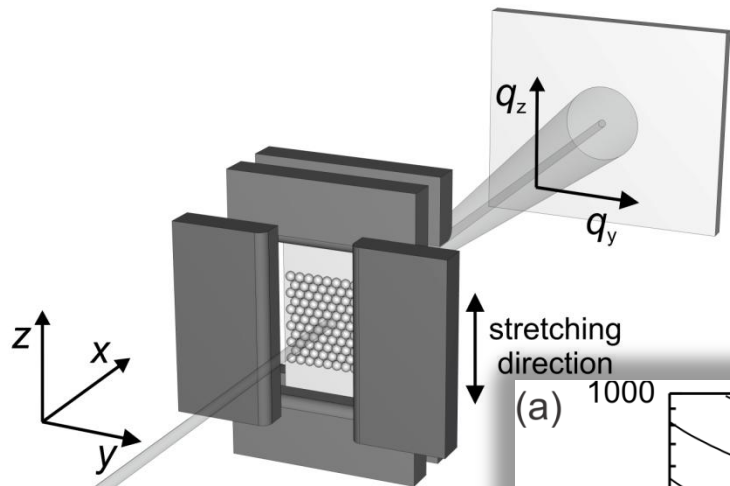
SAXS in applied nanoparticle science / strain gauges

Strain gauge sensors based on nanoparticle assemblies



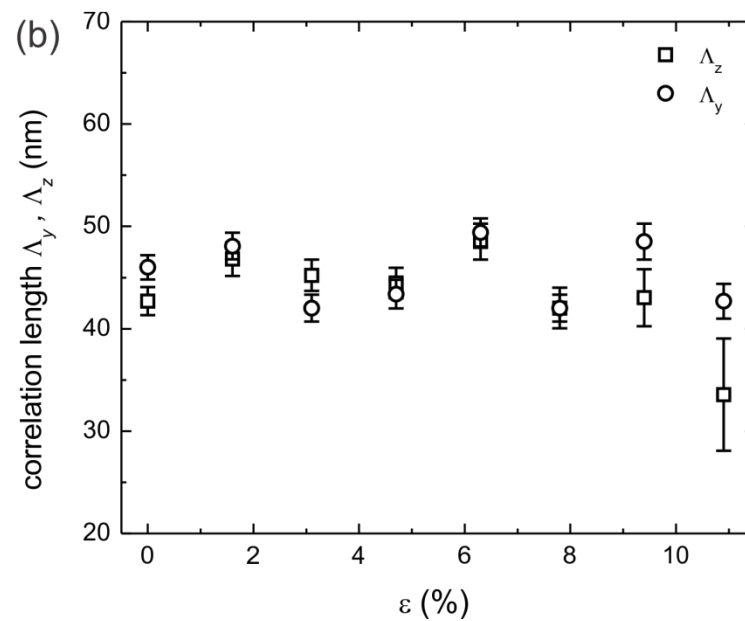
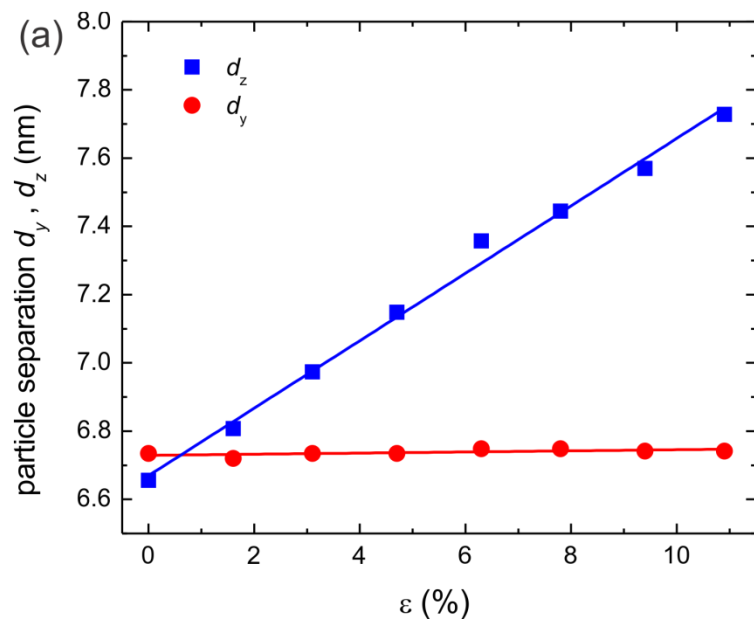
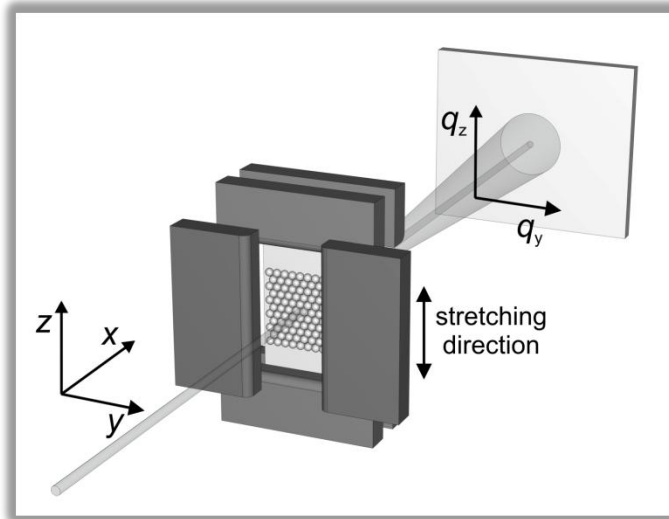
SAXS in applied nanoparticle science / strain gauges

Strain gauge sensors based on nanoparticle assemblies

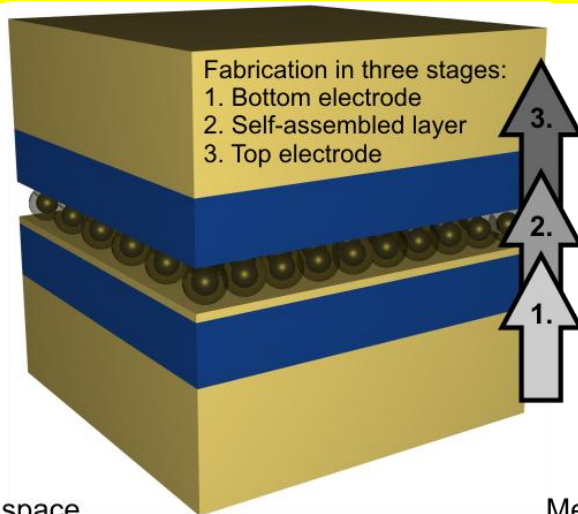


SAXS in applied nanoparticle science / strain gauges

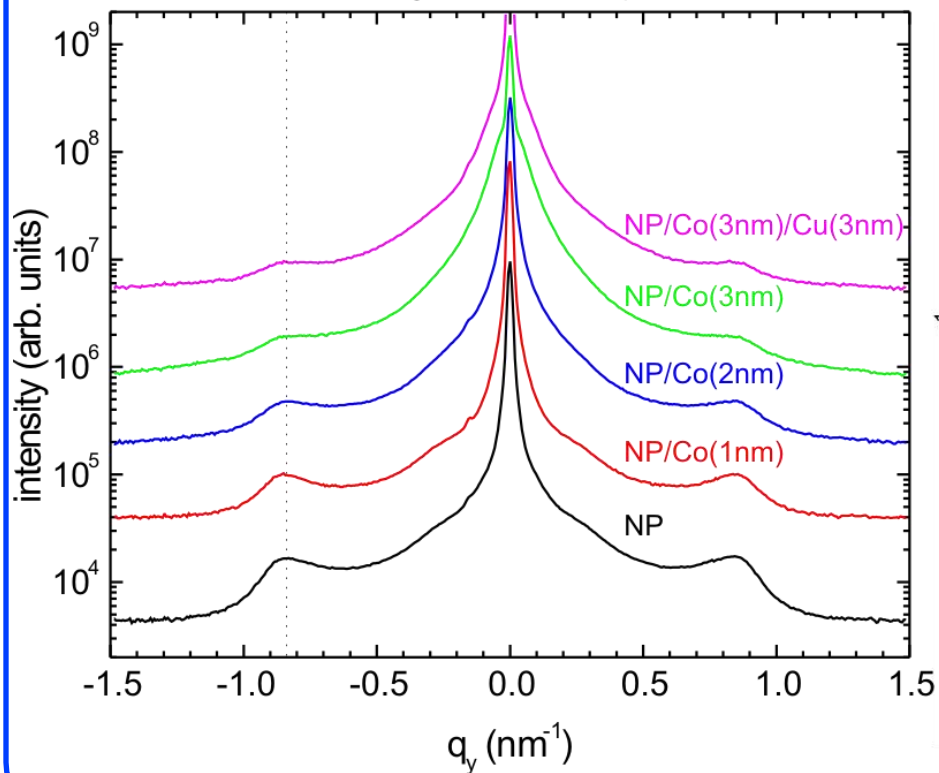
Strain gauge sensors based on nanoparticle assemblies



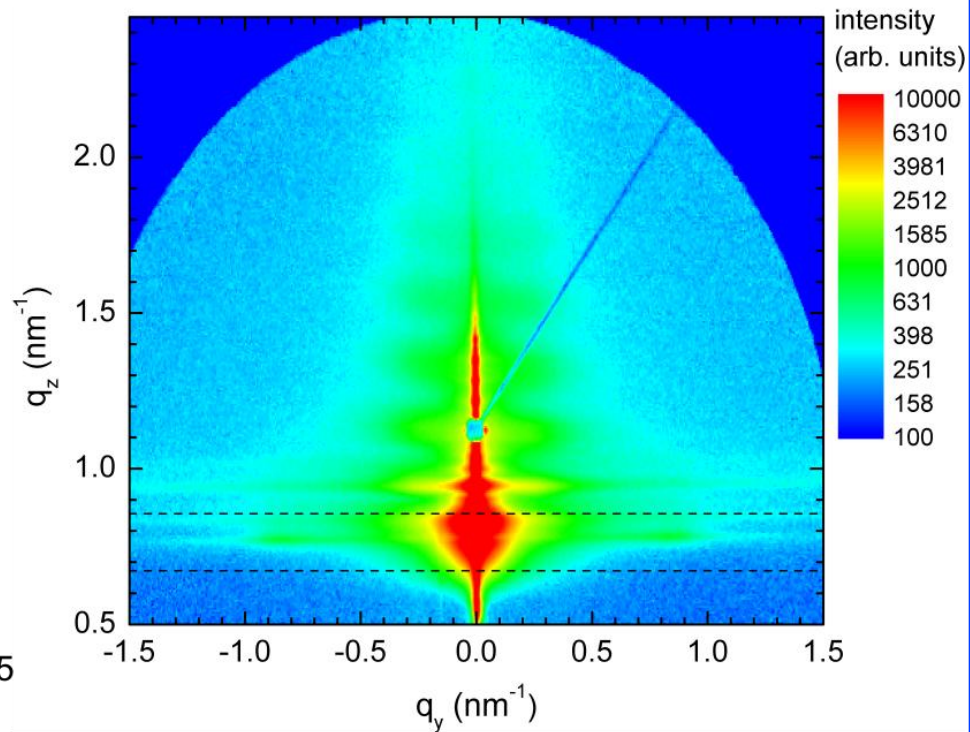
GISAXS in applied nanoparticle science / nanospintronics



Evolution of scans in reciprocal space with increasing thickness of top electrode



Measured GISAXS pattern of complete hybrid TMR structure



- **GISAXS together with XRR provide unique set of measurements for characterization of buried nanoparticles at interfaces and their replication**
- **GISAXS provide possibility for ex-situ measurements and in-situ monitoring of nanoparticle layer growth**

